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Flexible Barrier Materials

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Barrier materials



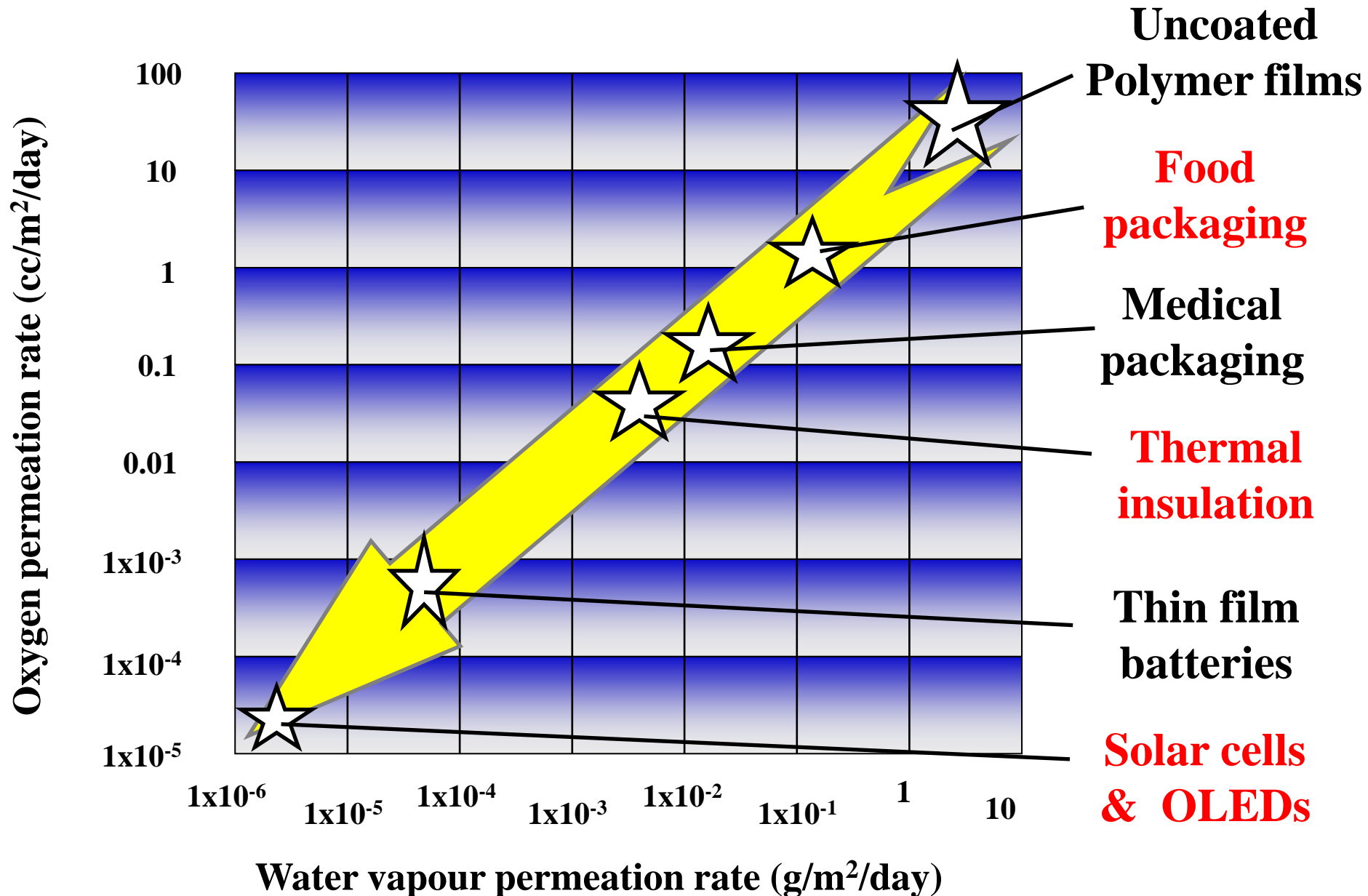
Clay

Glass



Tin Can

Range of barrier performance



Properties

Light barrier

Moisture barrier

Gas (Oxygen) barrier

Odour / taint barrier

Modified Atmosphere Packaging - CO₂ - ethylene – etc

Chemical / biological / anti-bacterial / anti-microbial / antiseptic

EMI/RFI screening, Anti-static

Decorative / aesthetics / convenience

Mechanical – containment – heat seal – puncture resistance

Food Degradation

Rancid – fats affected by light & oxygen

Soggy – moisture absorption

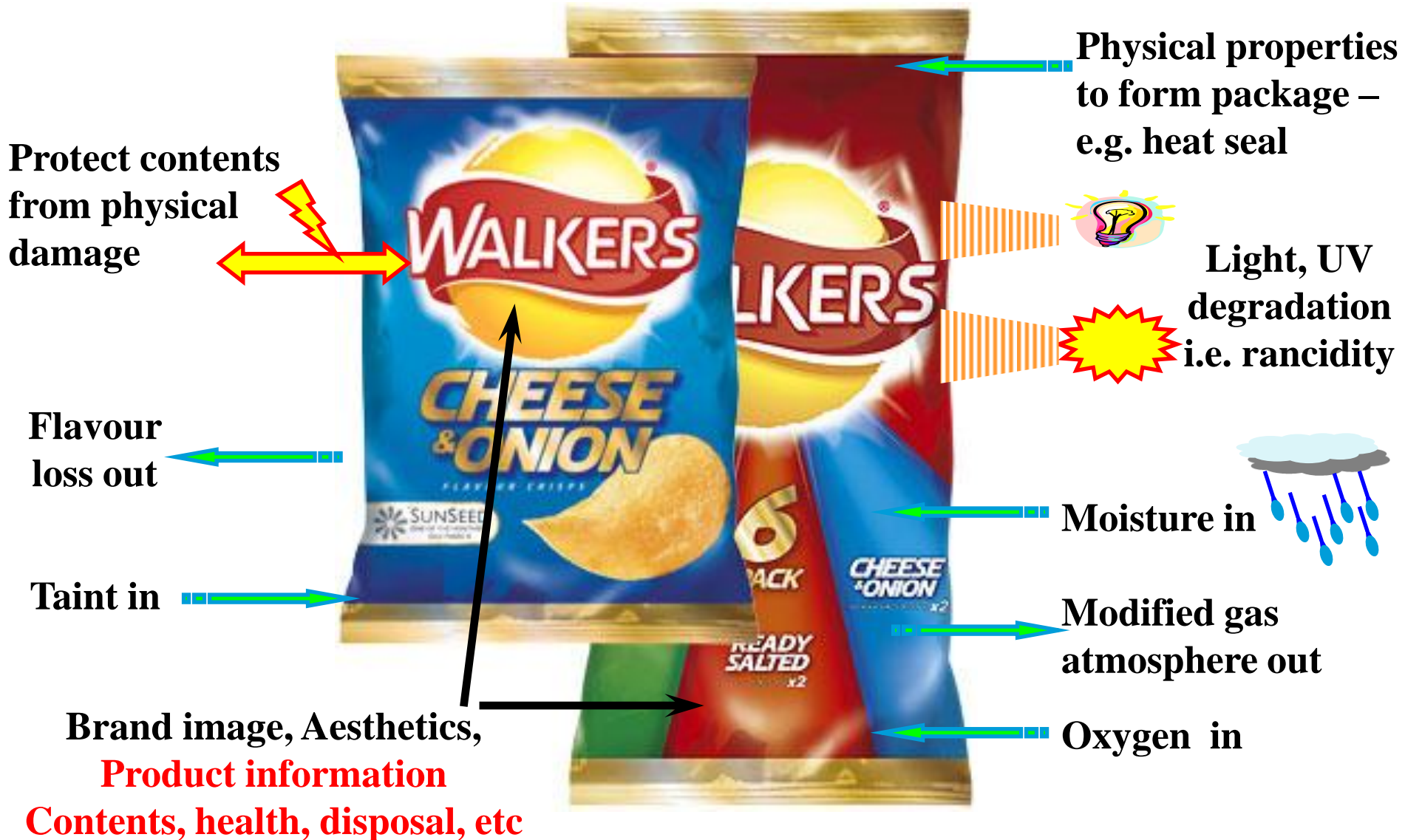
Taint - loss of flavour or alteration of aroma

Loss of colour

Loss of texture – bloom on surfaces

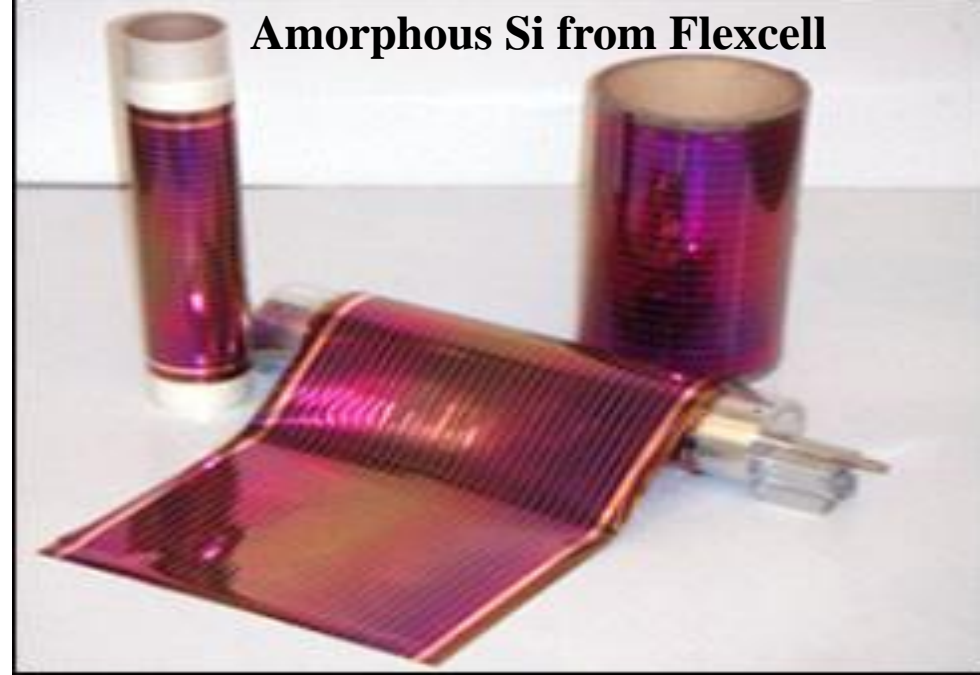
Degradation – mould growth, chemical interaction, etc

Total packaging performance

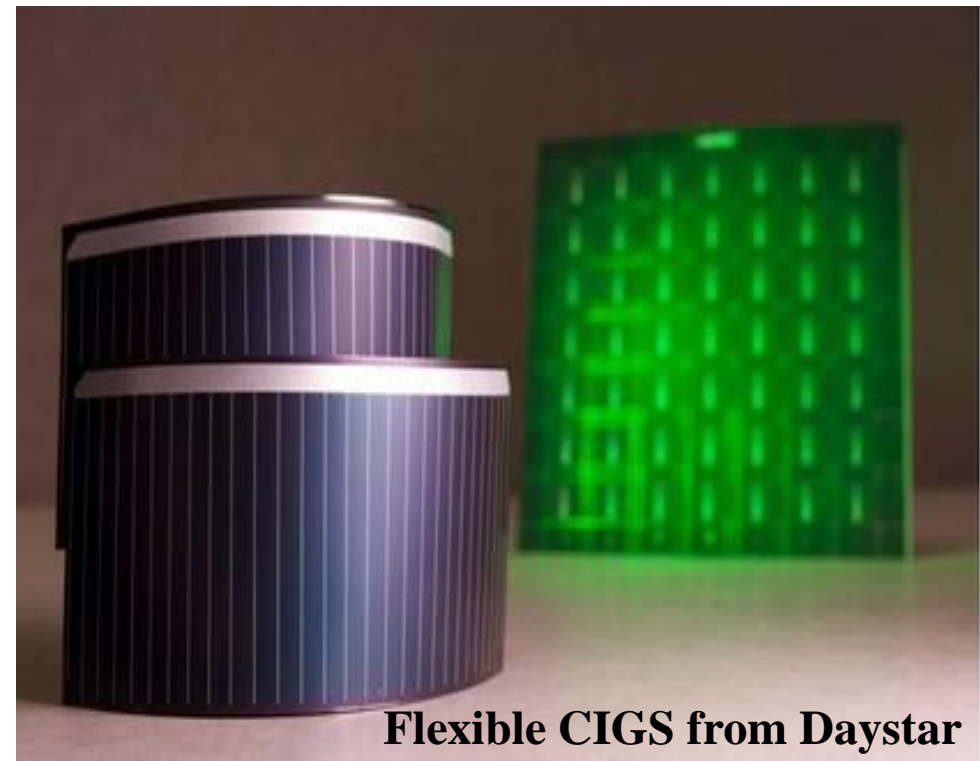
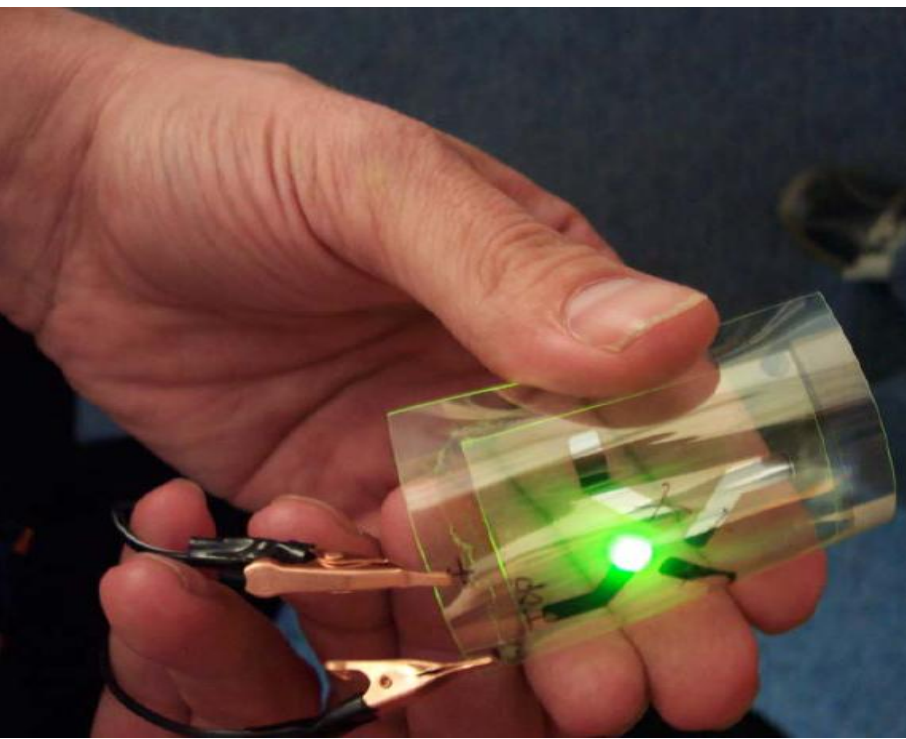




General Atomics OLED demonstration devices

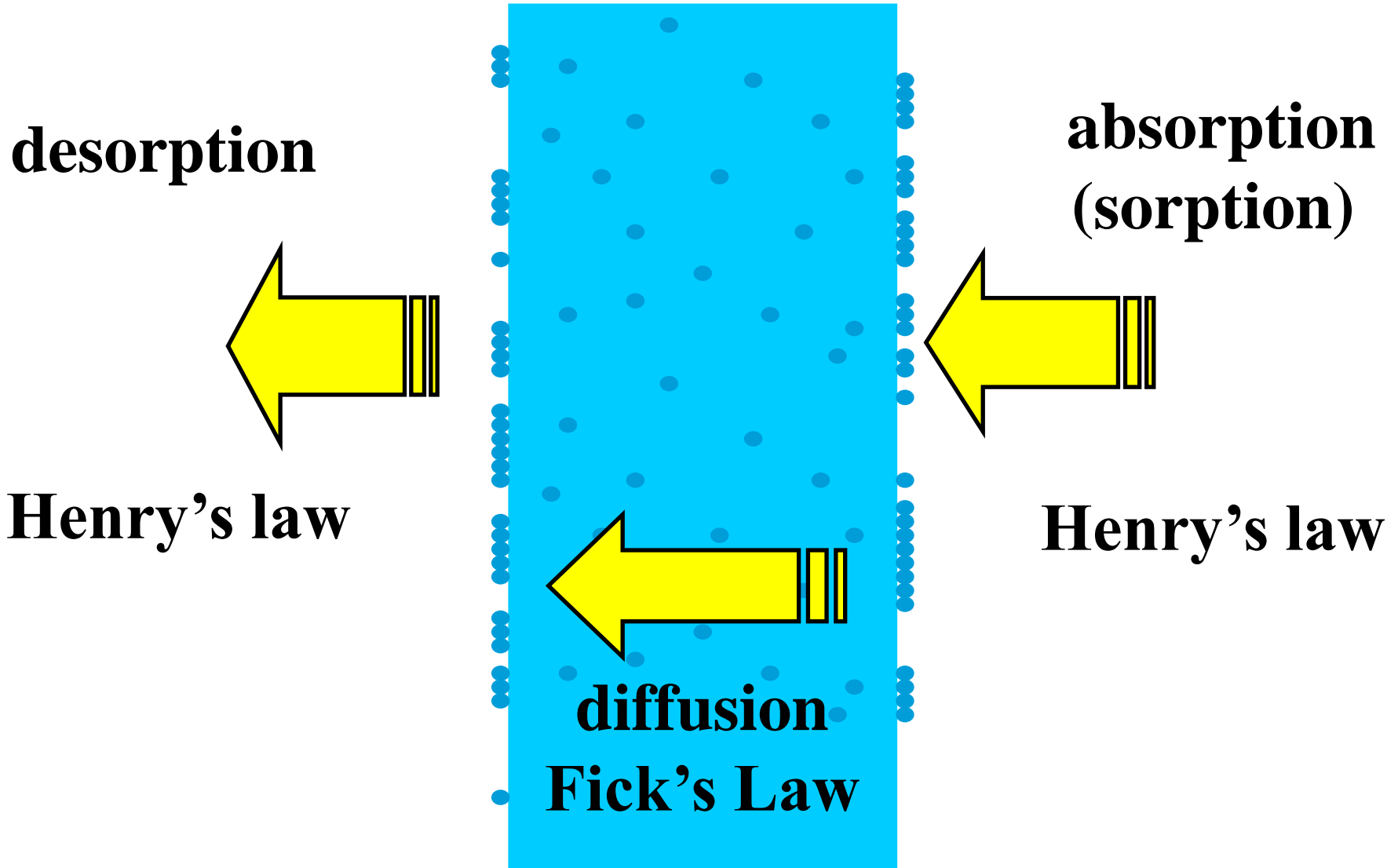


Amorphous Si from Flexcell



Flexible CIGS from Daystar

Permeation



Diffusion coefficients

Diffusion Coefficients

Oxygen in air

$$D_{O_2} = \mathbf{0.15 \text{ cm}^2/\text{s}}$$

Oxygen in Water

$$D_{O_2} = 2 \times 10^{-5} \text{ cm}^2/\text{s at } 20^\circ\text{C}$$

Oxygen in Quartz

$$D_{O_2} = 10^{-25} \text{ cm}^2/\text{s}$$

Oxygen in Silica

$$D_{O_2} = \mathbf{10^{-13} \text{ cm}^2/\text{s}}$$

Oxygen in Silica Gel

$$D_{O_2} = 10^{-3} \text{ cm}^2/\text{s}$$

Oxygen in Polypropylene

$$D_{O_2} = \mathbf{10^{-7} \text{ cm}^2/\text{s}}$$

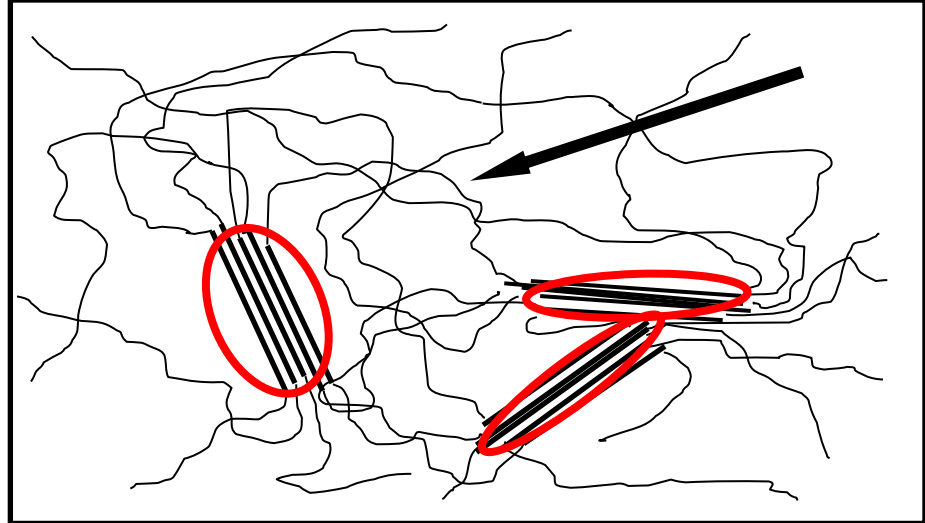
Oxygen in Polyester

$$D_{O_2} = \mathbf{10^{-9} \text{ cm}^2/\text{s}}$$

Water vapour in air

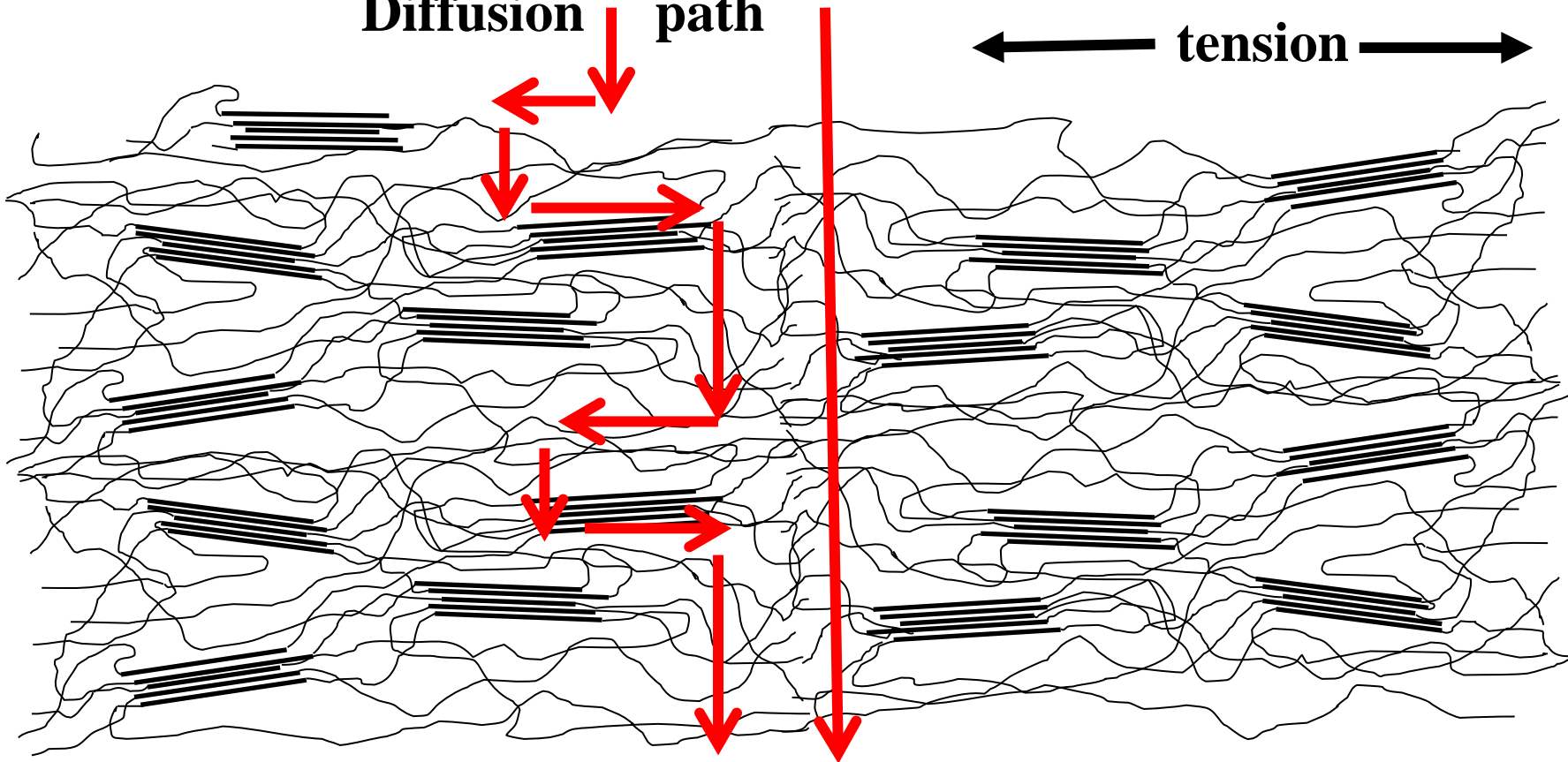
$$D_{H_2O} \approx \mathbf{0.26 \text{ cm}^2/\text{s}}$$

Biaxial substrates

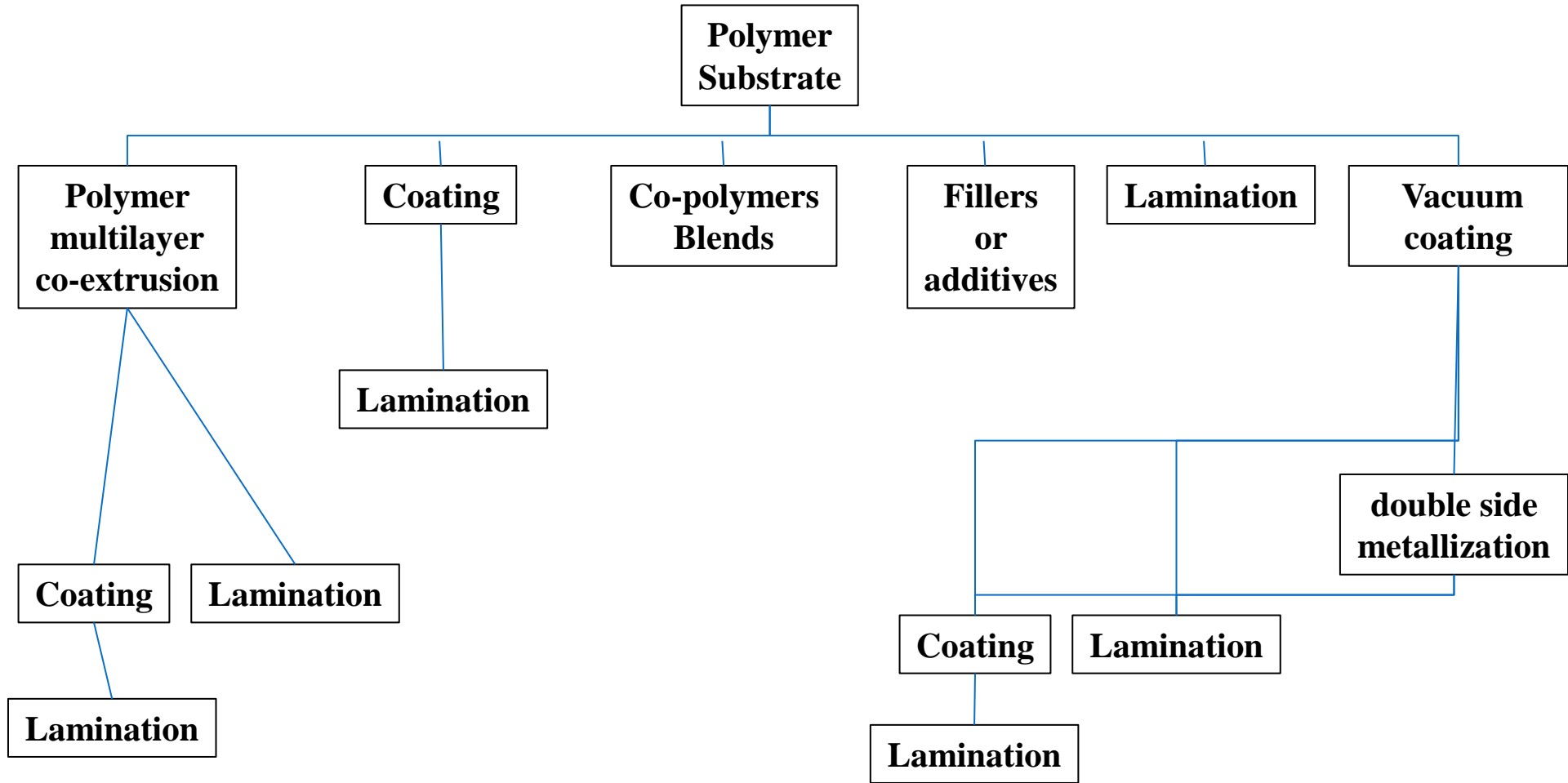


Diffusion path

tension



Basic structures



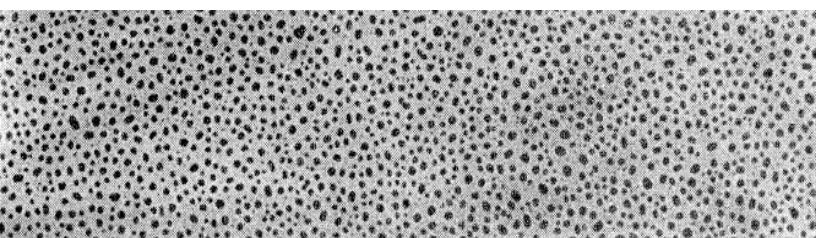
Polymers or coatings can be with or without fillers

Barrier performance

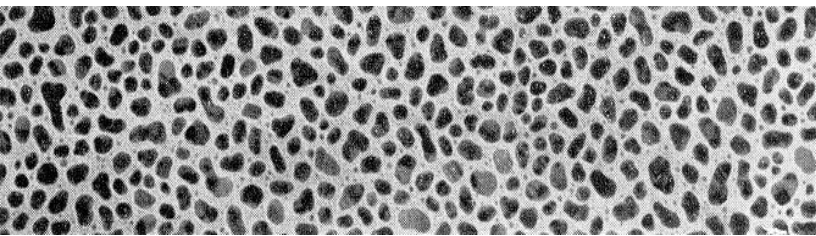
- **Performance of multi-layers dependent upon:-**
- **Adhesion**
 - Dependent upon surface roughness, quality & cleanliness
 - Dependent upon surface energy & wetting (**wetting \neq adhesion**)
 - Dependent upon amount & type of surface treatment
 - Dependent upon chemical bonding
- **Quality of materials, coating technique & handling**
 - Including filtration of coatings
 - Density of coatings
 - Dependent upon deposition process
- **Minimise handling – protect fragile coatings**



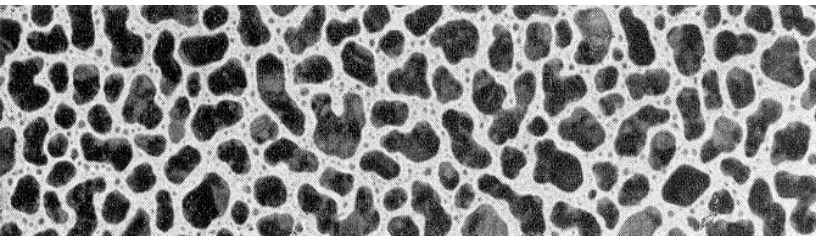
0.001nm



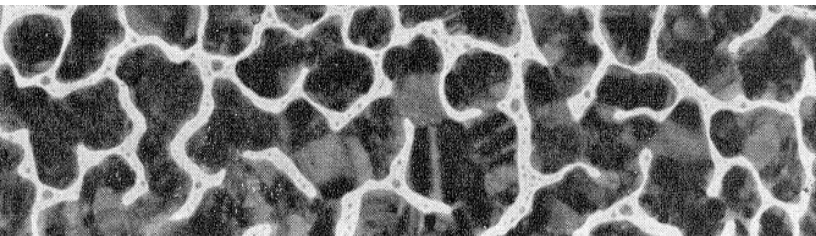
0.5nm



3.0nm



6.0nm



15 nm



50 nm

Nucleation & Film Growth

Gold nucleating onto glass

Transmission Electron
Micrographs (TEM)

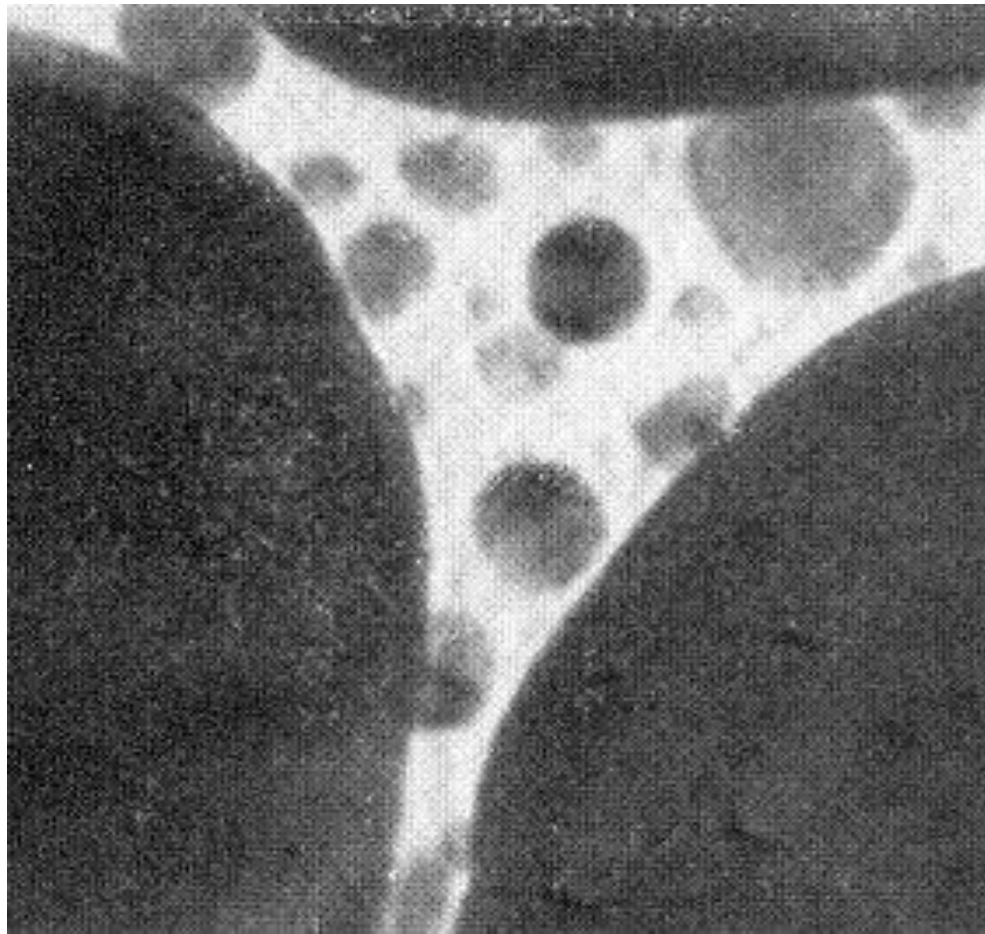
75,000x Magnification

**The thickness indicated is for
a film of equivalent mass that
is continuous & parallel**

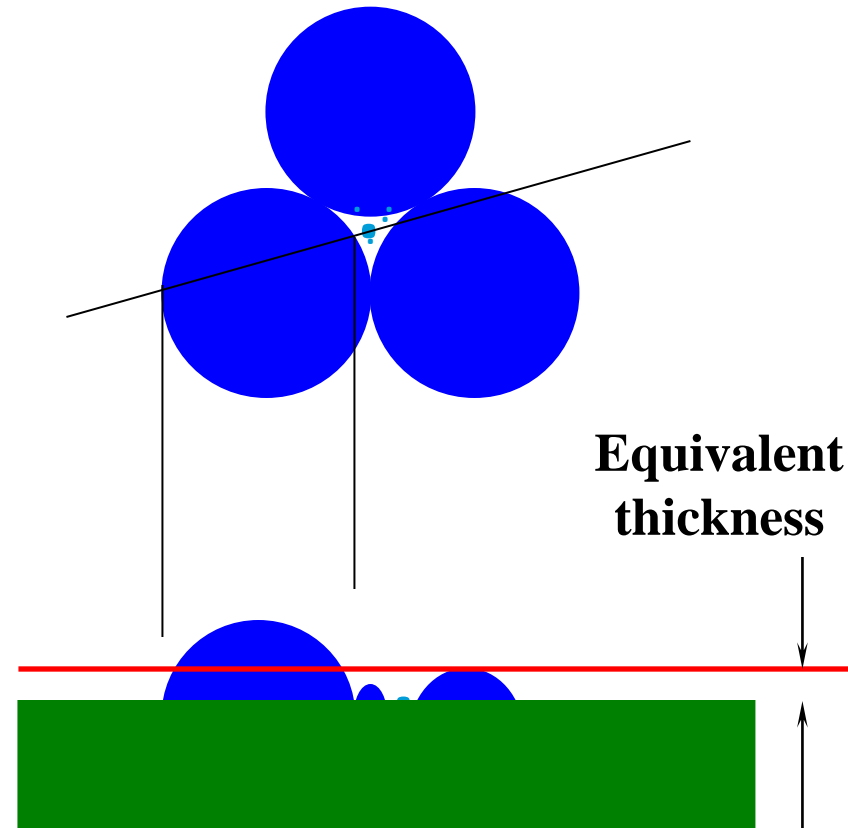
R.M.Hill

Contemp Phys. 1969 Vol 10 No 9 pp 221-240

Nucleation & Film Growth



500,000 x magnification



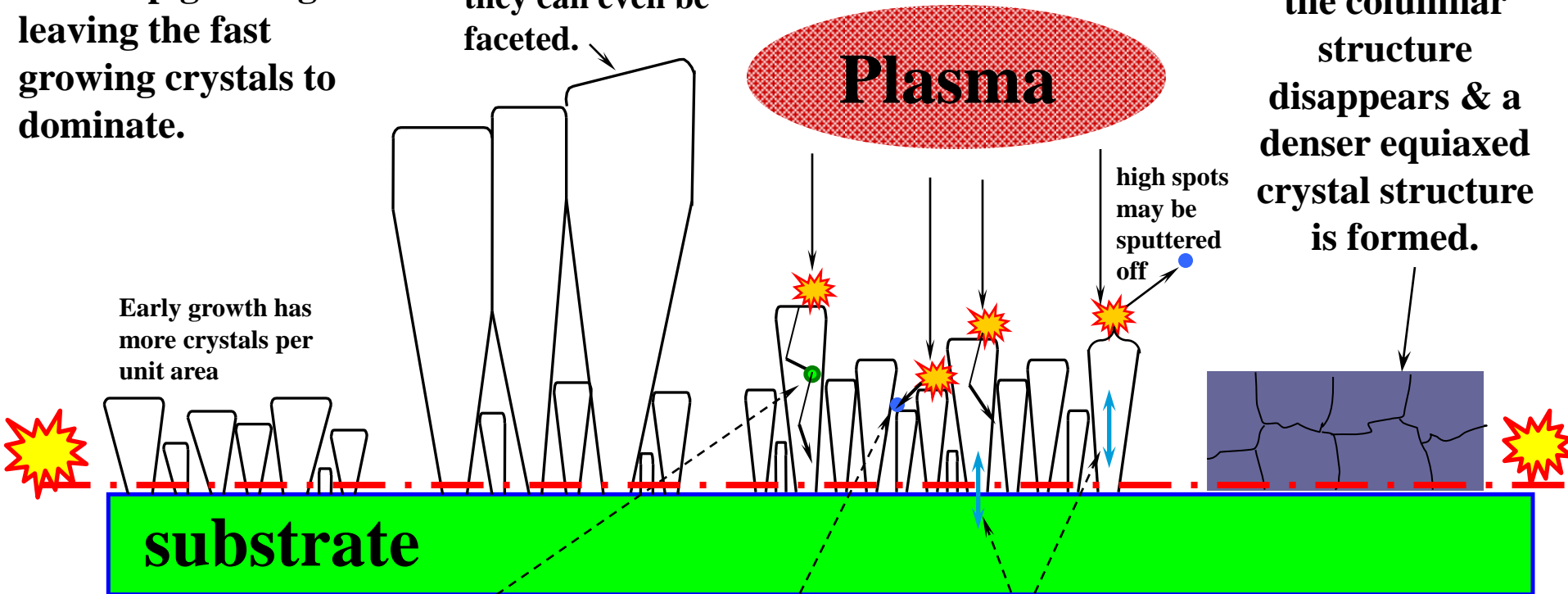
In reality the coatings can be quite thick but still contain defects or holes that reach the substrate. High surface energy & good wetting help minimise this

Microstructure modification

Slow growing crystals are shadowed & starved of material & thus stop growing leaving the fast growing crystals to dominate.

Thicker films show more surface texture, they can even be faceted.

Following bombardment the columnar structure disappears & a denser equiaxed crystal structure is formed.

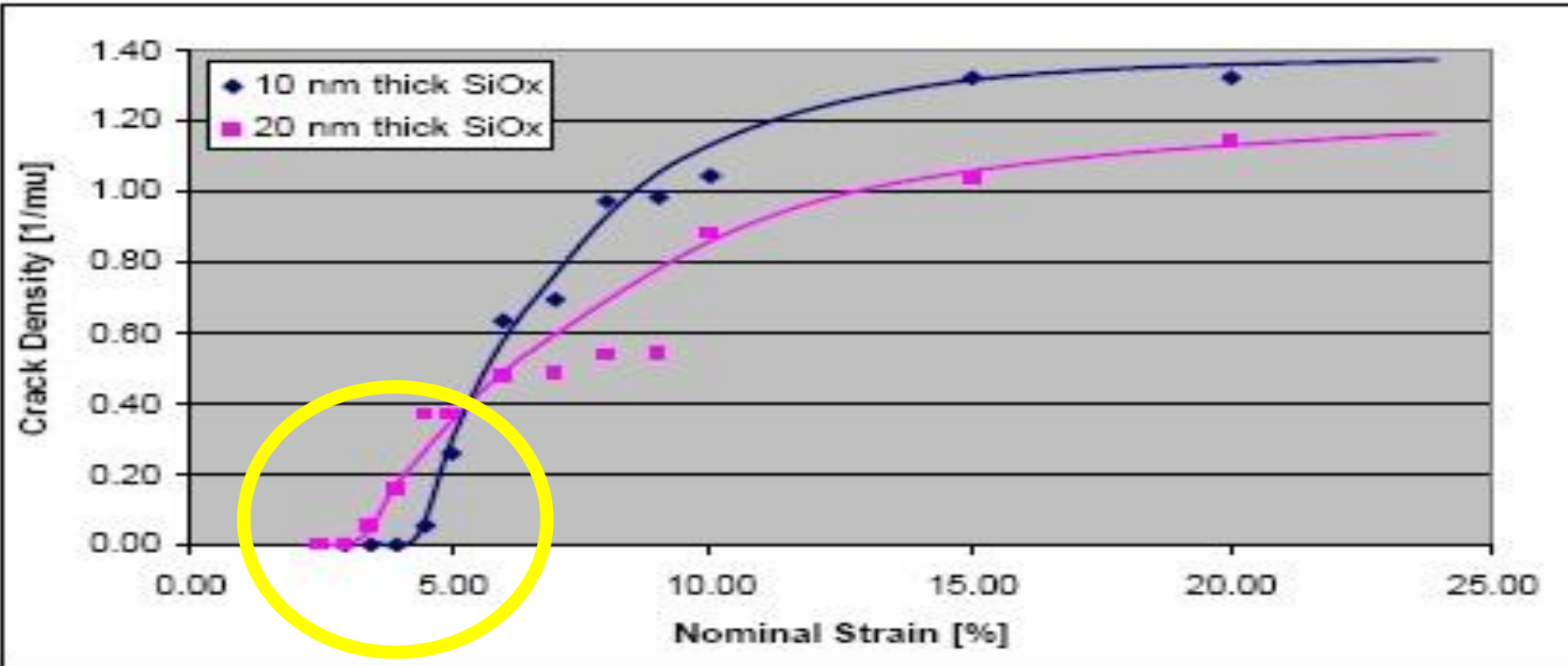


The impacting ions can displace atoms causing point defects

Atoms can be displaced & deposit into shadowed areas

Enhanced diffusion including at the interface & into the substrate surface giving interfacial mixing

Onset of cracking



Sample	SiOx thickness [nm]	Crack Onset Strain [%]
SiOx / PET (RDO12)	20	3.5
	10	4.5

Materials

Polymers / organic materials

Substrates

Polyester (PET,PEN)

Polypropylene (PP, OPP, CPP)

Polyethylene, (PE, LDPE, HDPE, Linear LDPE, ULDPE....)

Polyamide (Nylon)

Biopolymers

Others

Cyclic Oxalic Copolymers (COCs)

Liquid Crystal Polymers (LCPs)

Polycarbonate (PC)

Coatings

Ethylene vinyl alcohol (EVOH) - Polyvinyl alcohol (PVOH)

Poly vinyl dichloride (PVdC) – **(banned in some countries)**

Adhesives (heat seal, lamination, polyurethanes, polyethylene...)

Acrylates (inc. in-vacuum coatings)

Inorganic coatings

Compounds

Silica, silicates

Alumina

Metal oxides – ITO, SnO, ZnO, etc

Metal nitrides

Metal oxynitrides

Metal carbides, oxycarbides, etc

Graded compounds

Metals



Aluminium

Others

Carbon

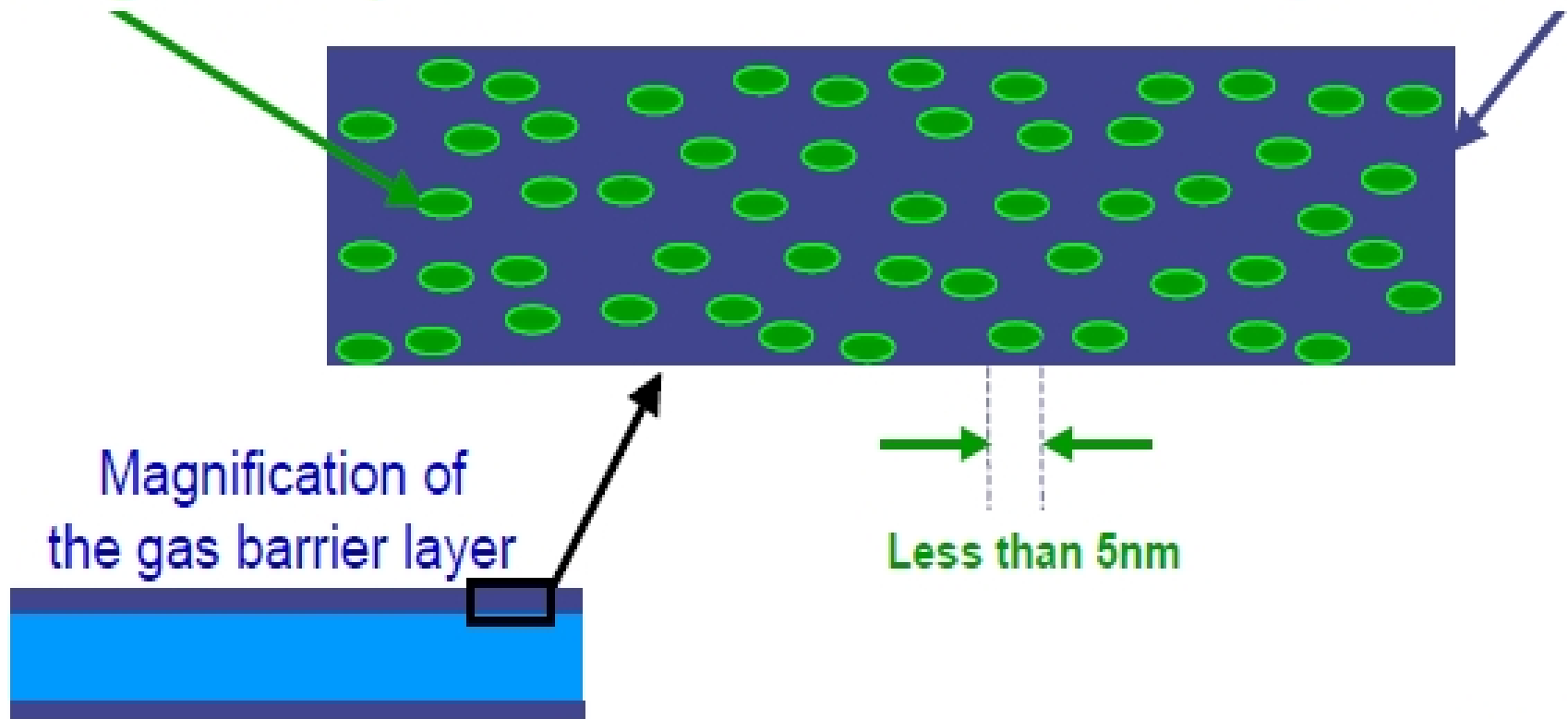
Melamine (1,3,5-triazine-2,4,6-triamine)

Kuraray's technology at work

-  An inorganic compound is dispersed in a polymeric matrix, to create a tortuous path for gas molecules (long gas diffusion path).
-  Molecular movement of the polymer chain is restricted by the inorganic compound (low gas diffusion rate).

Inorganic compound

Polymeric matrix



Barrier Material	Thickness	Oxygen Transmission [ccm/m2/day/atm]	Water Vapour Transmission [g/m2/day/atm]	Deposition Process	Coating type	Relative cost
PET / Blank	12.00 μm	100	64.64			1x
PVDC	24.00 μm	8	0.3			
EVOH	24.00 μm	0.16 - 1.86 *	N/A			3x
m-OPA	15.00 μm	30				
Aluminized PET (single)	~ 30nm	0.31 - 1.55	0.31 - 1.55	Evaporation	Al	2x
Aluminized PET (double)	~ 30nm each	0.03	N/A	Evaporation	Al	~3x
Aluminium on PE	7μm Al	0.001	N/A	Laminated	Al	
SiOx on PET	10 - 80 nm	0.35 - 10**	0.46 - 1.24	Evaporation	SiOx	3x
SiOx on PET or SiOx containing Carbon	10 - 80 nm	0.08 - 1.55	0.5 - 5.0	PECVD	SiOx or Si(C)Ox	3x
Al2O3 on PET	20 nm	1.5	5	Evaporation, or Reactive Evaporation	Al2O3	2.25x - 2.5x
Al2O3/SiOx on PET	50 nm	2.0 - 3.0	1	Evaporation	Al2O3/SiOx	2.5x - 3x
Al2O3 on PET	<5 nm	~1.5 (improving 0.0001 claimed)	~5 (improving 0.0001 claimed)	ALD - Atomic Layer Deposition	Al2O3	aim to be < 2x
Diamond-like Carbon on PET	20 nm	2	1.5	PECVD	Carbon (DLC)	2.5x - 3x
Melamine on PET	12.00 + 0.25μm	<5		PVD	Triazine	2.5x - 3x
Melamine on OPP	20.00 + 0.25 μm	30		PVD	Triazine	2.5x - 3x
OPP / Blank	20.00 μm	1600				

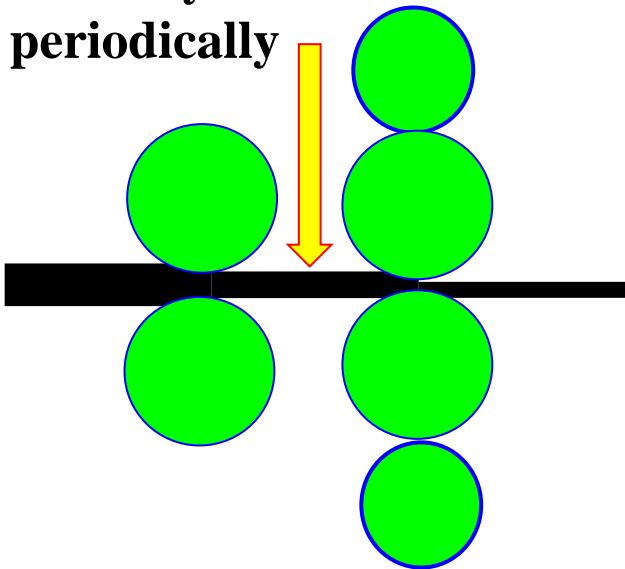
- * depending on relative humidity and ethylene content
- ** depending on process



Foil



Foil may be annealed periodically

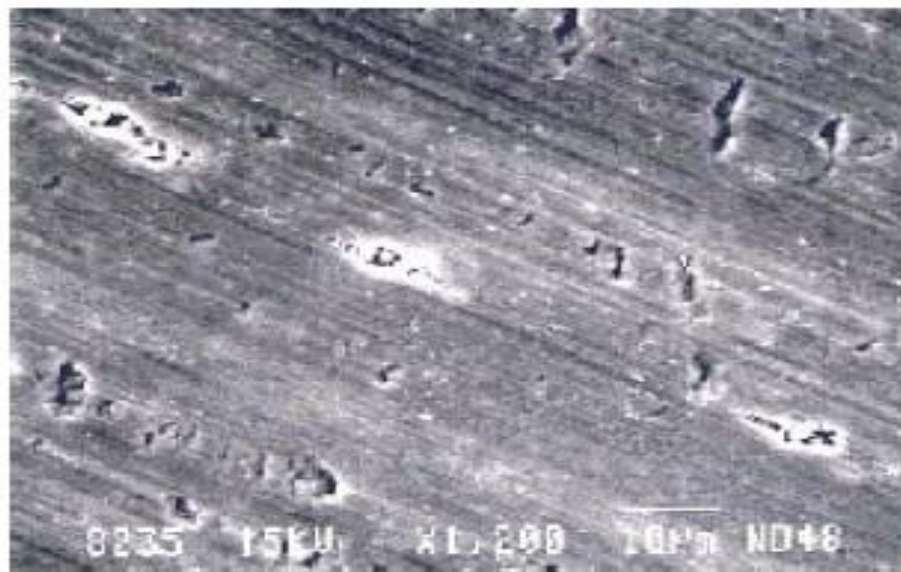


foil - 2.2m wide 2,500 m/min
6 microns thick

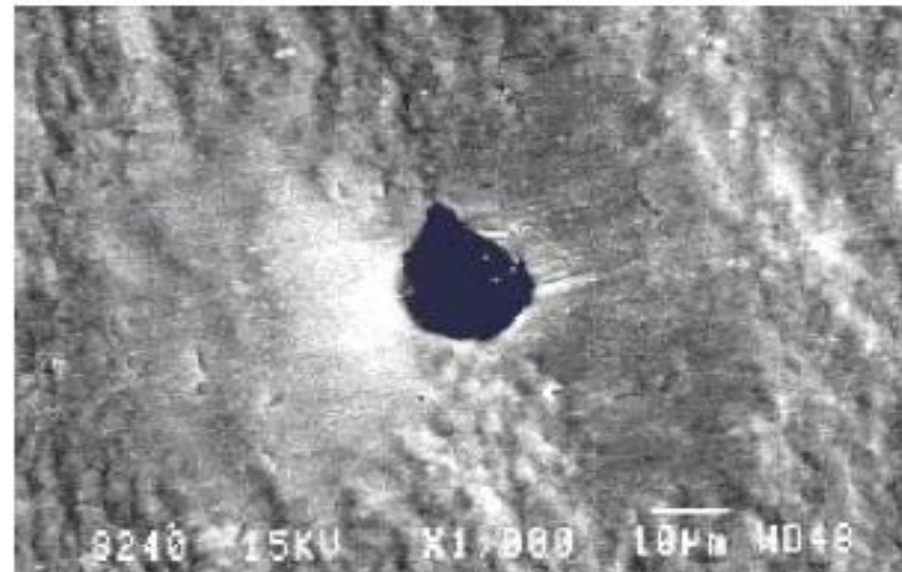
Maximum Allowable Pinhole Count in One Square Meter

Foil Gauge	Foil Caliper, μ	Average	Maximum
28.5	7	423	1584
35	9	211	1056
50	13	85	528
75	18	21	106
100	25	0	0

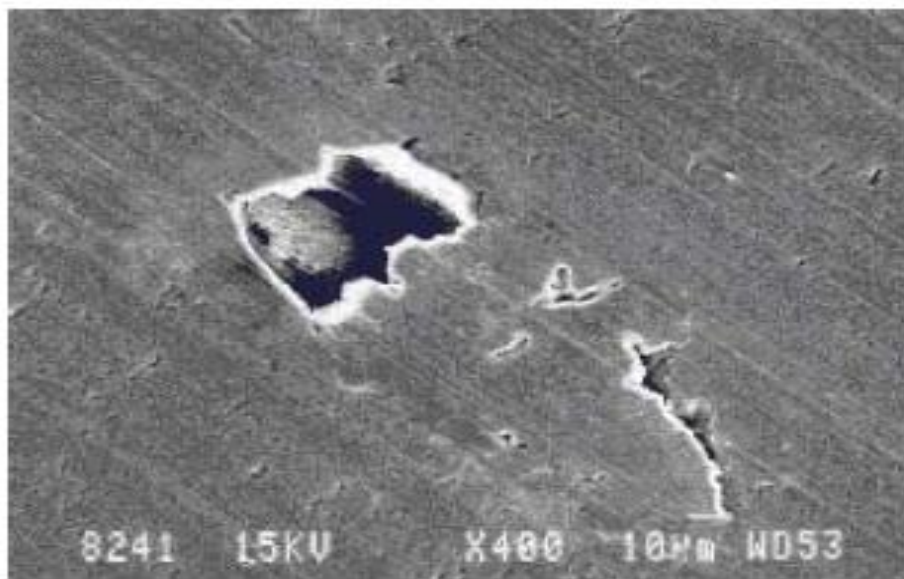
Examples of Typical Foil Pinholes



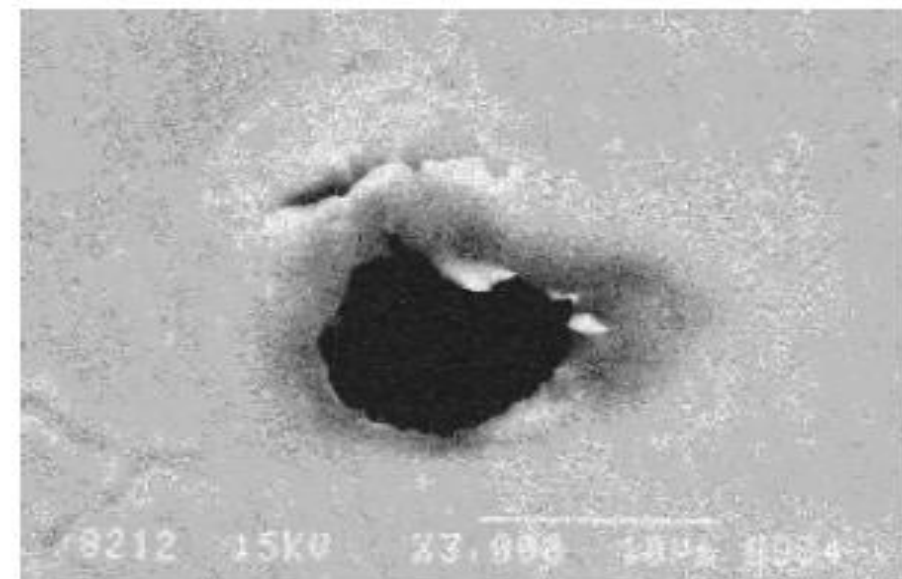
Pinholes from Al-Fe-Si Constituents



Pinhole from Depression in Foil

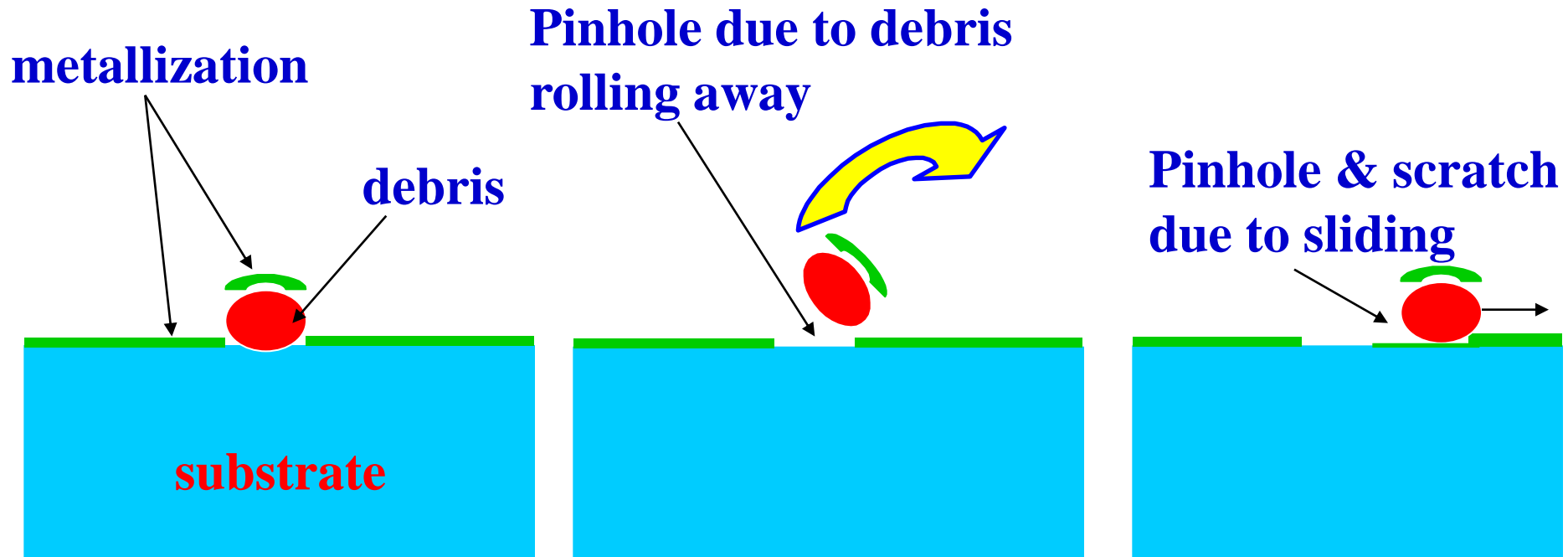


Pinhole from rolling Debris



Pinhole from Aluminum Fines Damage

Pinholes



Debris typically >0.5 microns

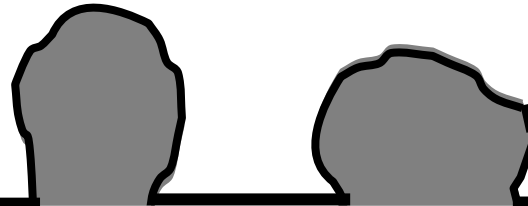
metalized layer 20 – 100nm



Loss of coating due to shadowing by debris from coating point source

Metallization or other PVD process

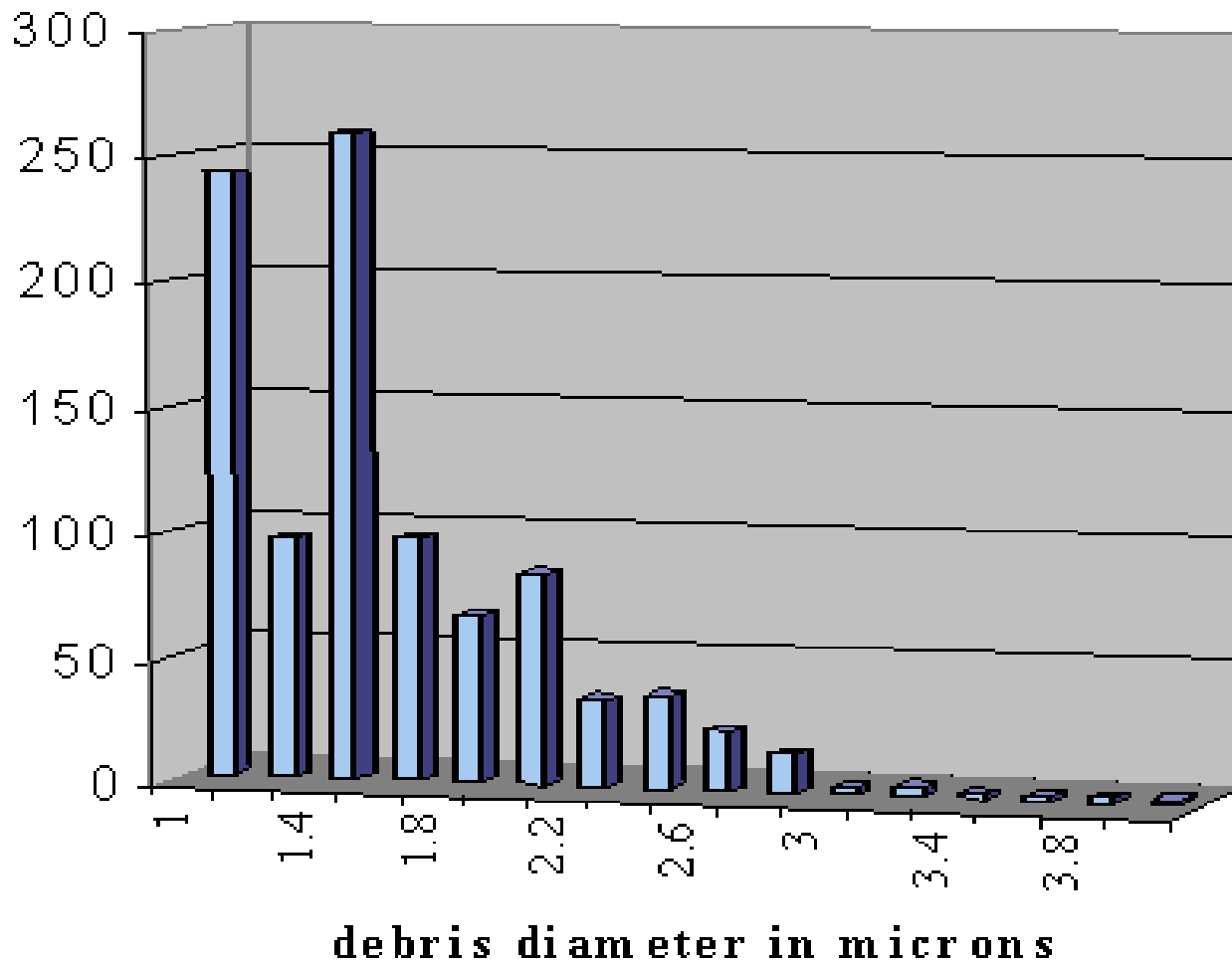
Atomic Layer Deposition (ALD)



ALD provides conformal coating over whole surface including into root of debris contamination or defects

Surface defects

Particle count

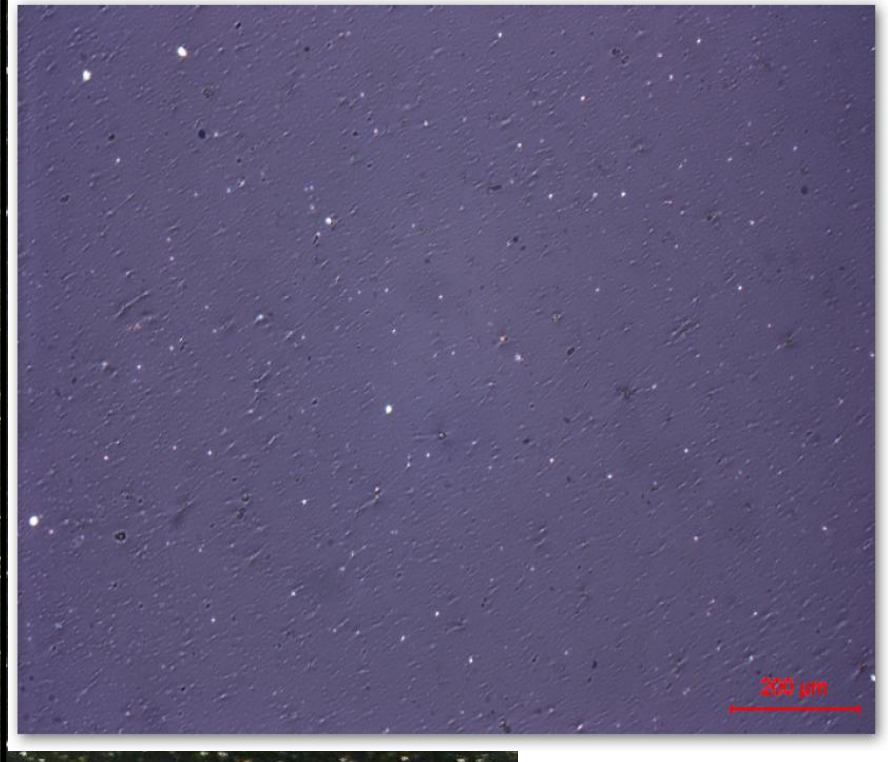


**Incident Dark Field
Optical Microscopy
Or
Differential Interference
Contrast Microscopy**

**Area used for the analysis
was **170 x 170 microns****

Magnification 400x.

**Average of 6 different
fields of view**



Comet

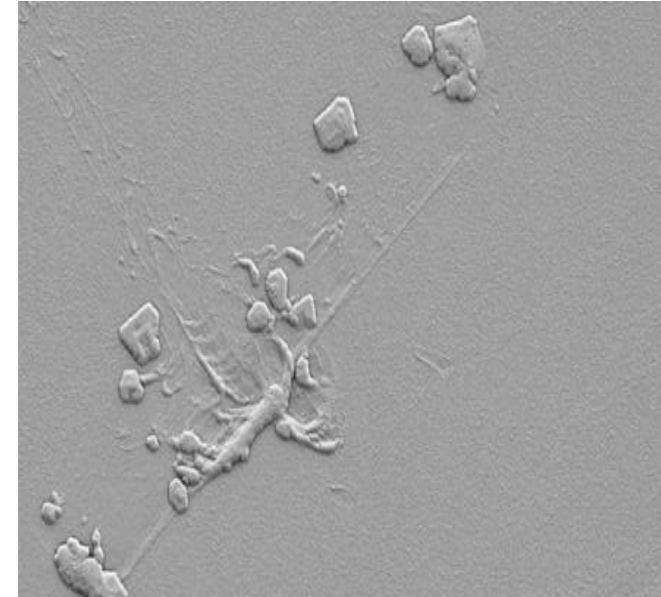
**Debris slides
causing pinhole
and scratch**



EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 12.84 K X FHG IPA 350



200 nm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 23.22 K X FHG IPA 350 ZEISS

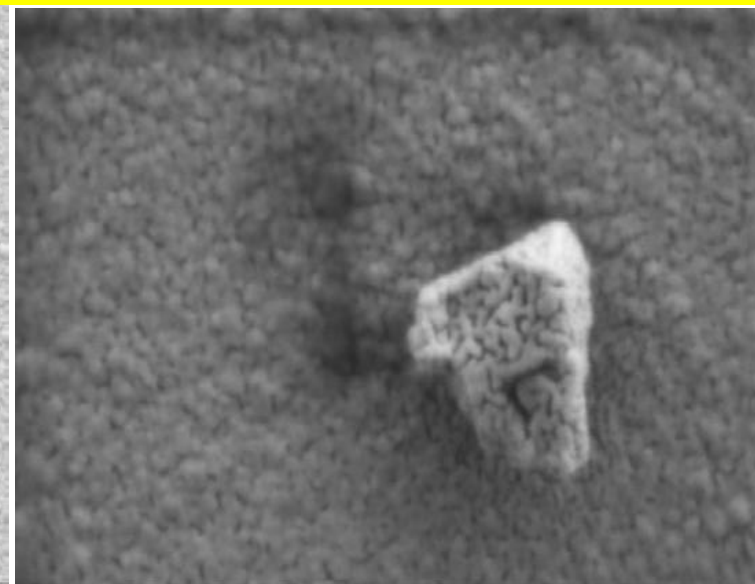


2 µm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 7.48 K X FHG IPA 350 ZEISS

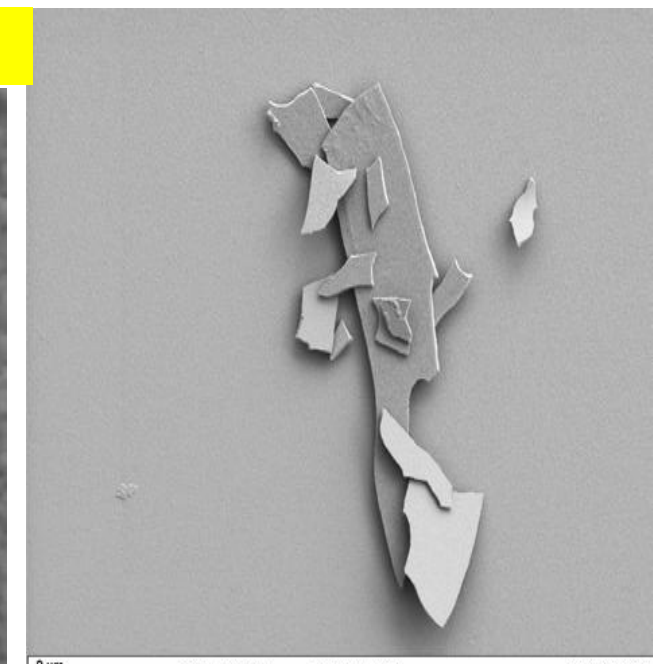
SEM of defects – FEP IVV Freising



200 nm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 30.74 K X FHG IPA 350

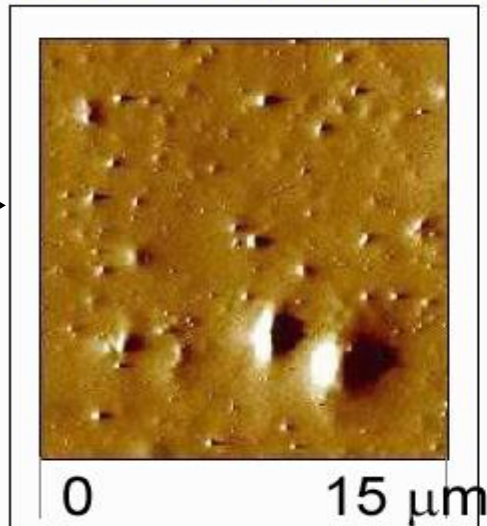


200 nm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 86.95 K X FHG IPA 350 ZEISS

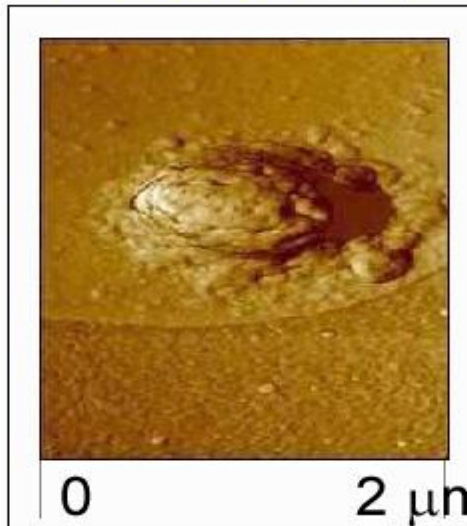


2 µm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 3.03 K X FHG IPA 350

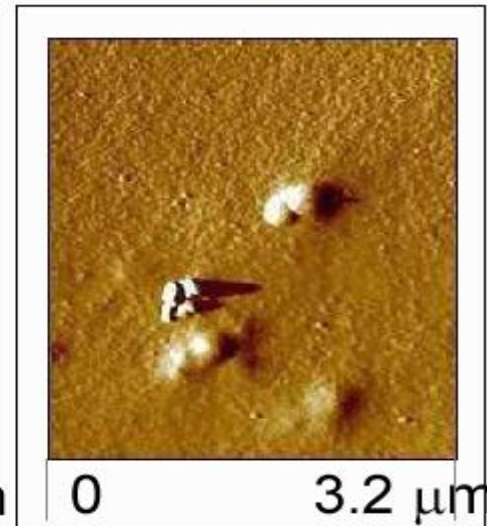
Defects of various sizes



Silica Anti-blocking

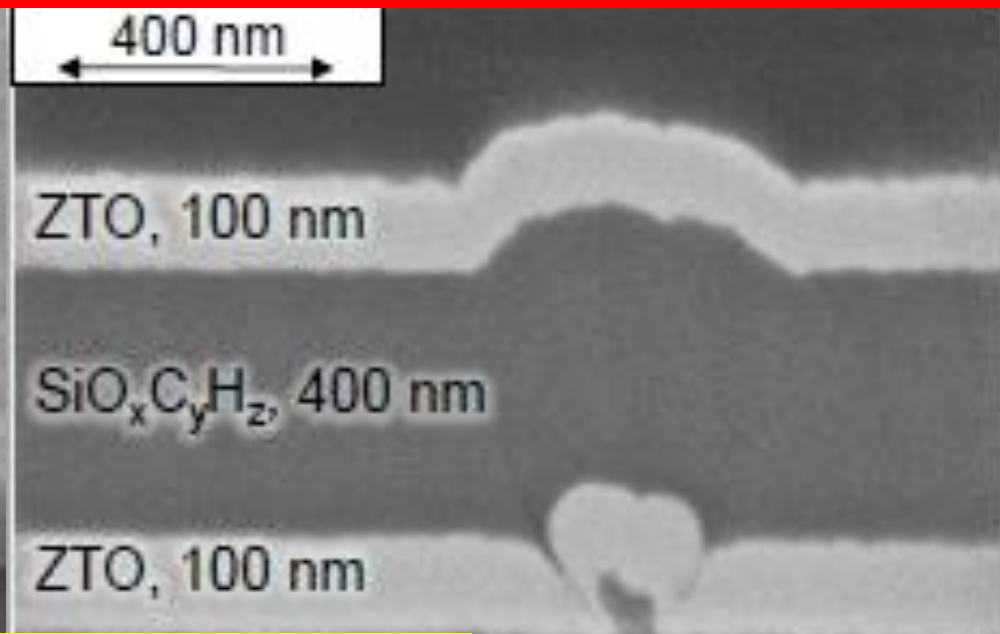
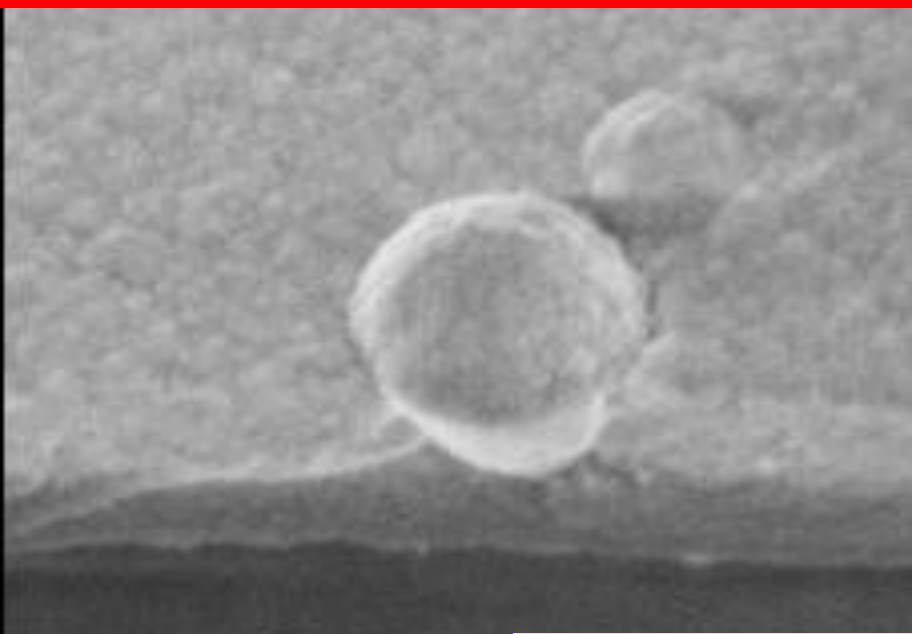


Dust particles



Images courtesy
of TetraPak →

Data from tapping AFM: Amplitude



SEM of nodule defects – FEP Dresden

Source of debris

People emit a very large number of particles

standing still humans emit 100,000 particles per minute (ppm)
standing up from a sitting position humans emit 2,500,000 ppm
(definition of a particle is debris of 0.5 microns or larger)

This comprises hair, skin and micro-salt crystals
skin in the range 0.1 – 5 microns Hair in the range 5 – 100 microns

Resolution of eye

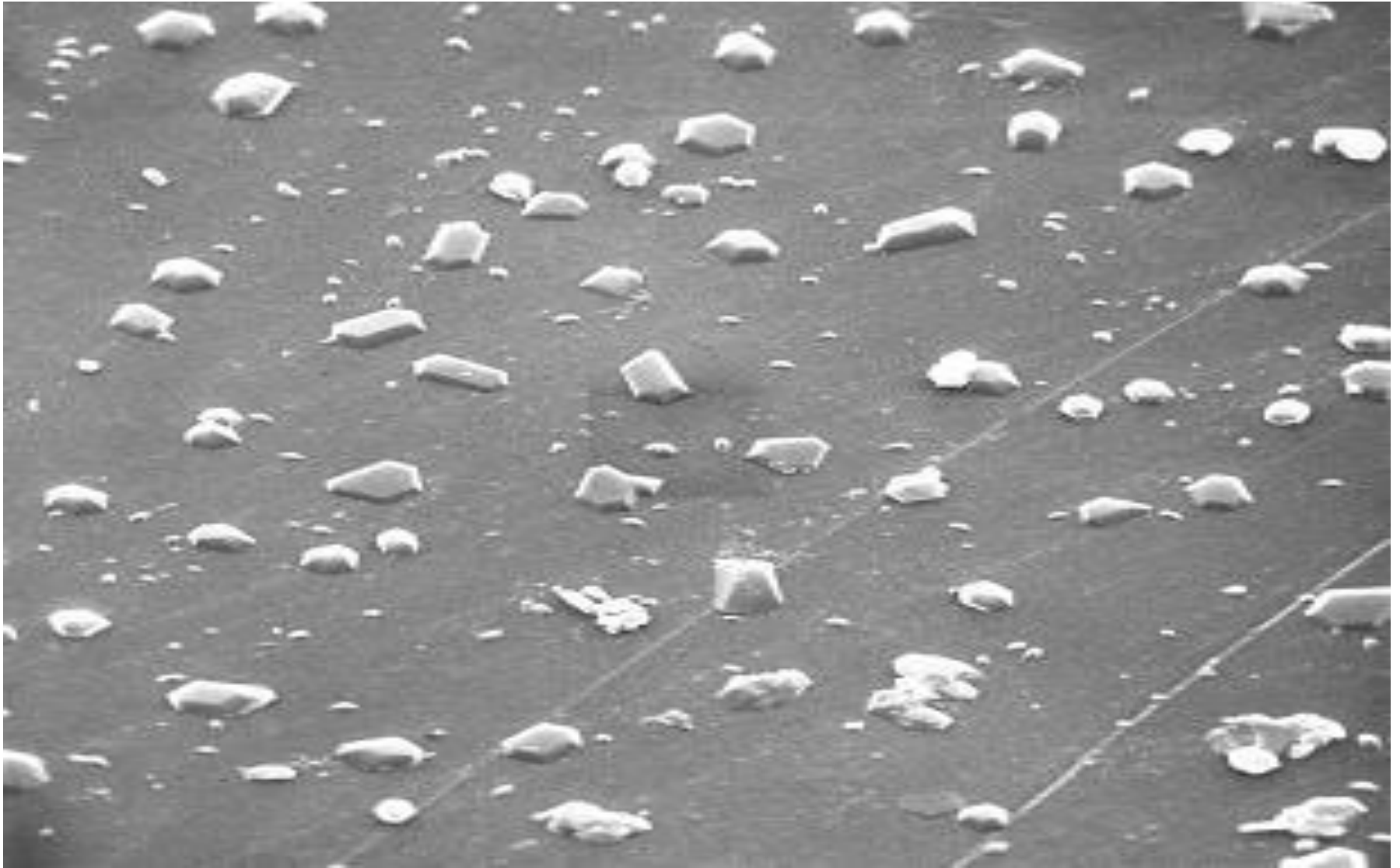
A working value ~50 microns
(quoted range 10 – 100 microns)

Practical example

Human inspection expected to
resolve 50% of 50 microns debris
on a surface

Activity generating particles	microns
Pollens	10 - 100
Rubbing ordinary painted surface	90
Sliding metal surfaces (unlubricated)	50 to 150
Crumbling or folding paper	60
Rubbing epoxy painted surfaces	30 to 75
Seating and unseating screws	25 to 120
Belt drive	5 to 35
Writing with ballpoint pen on paper	15 to 30

Oligomer growth



**PET (442) after prolonged heating 1hr @ 140 Deg C SEM at 2000x magnification
Showing growth of 'mer' units into dimers, trimers, etc**



Planariser

The image is a scanning electron micrograph (SEM) showing a cross-section of a film. The top portion is a smooth, dark grey layer labeled 'Planariser'. Below it is a layer labeled 'Uncoated PEN' which contains numerous small, light-colored, irregular crystalline particles. The boundary between the two layers is slightly wavy. At the bottom, there is a black bar with white text providing technical details.

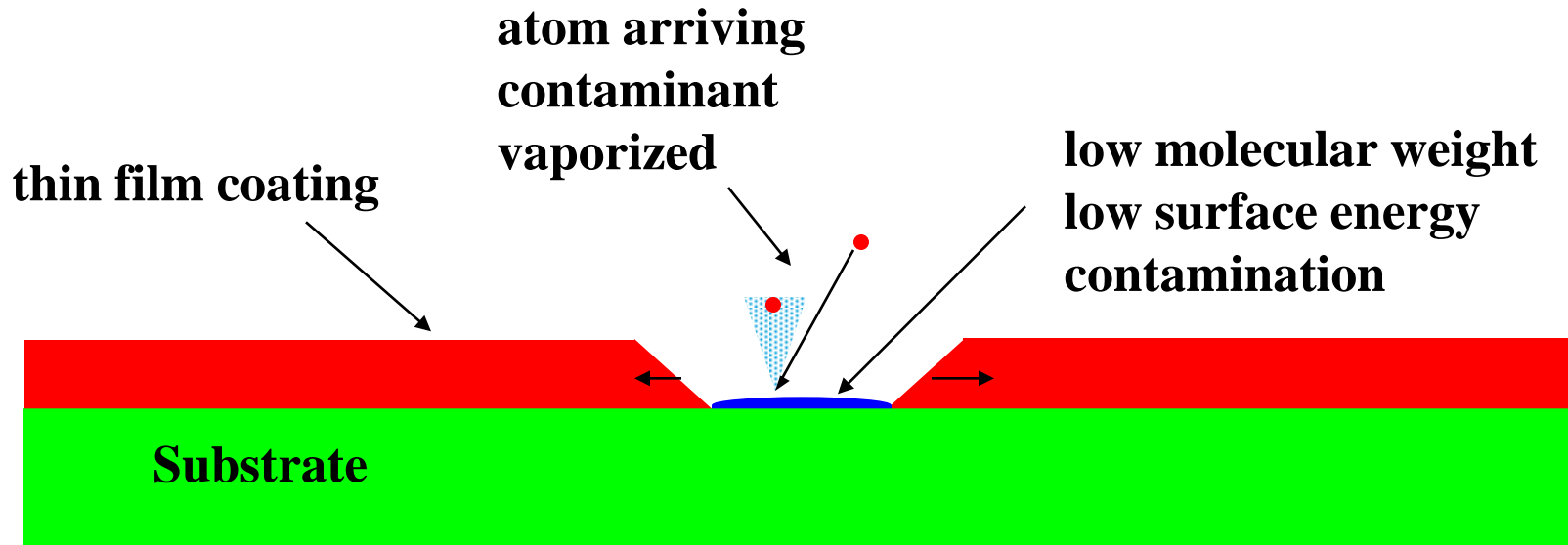
Uncoated PEN

433815 7.0 kV

30.0 μm

Reticulation pinholes

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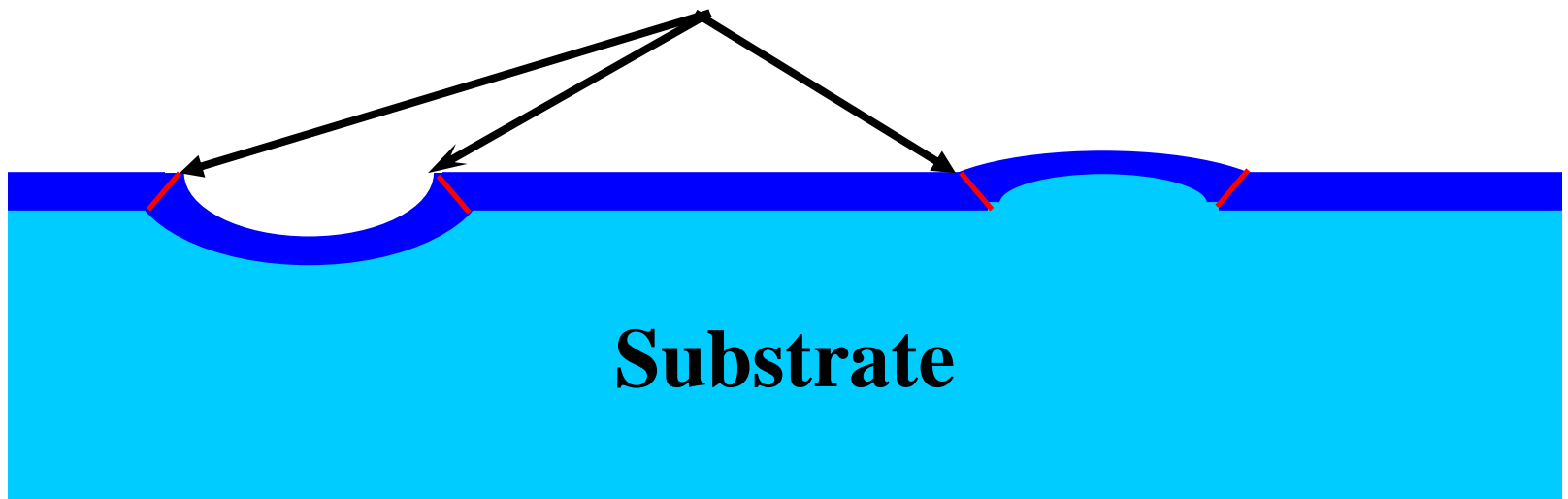
The atoms nucleate on the higher surface energy part of the substrate but not on the low molecular weight contamination

Low molecular weight contamination can be vaporized by depositing atoms preventing any deposition. This low molecular weight material may be oligomer

Stress raisers

Surface defects i.e. dents or bumps lead to defects in the coatings

The coating thinner over the defect ($>$ surface area for same coating thickness) & also the edges of the defect are prone to cracking



Cleaning options

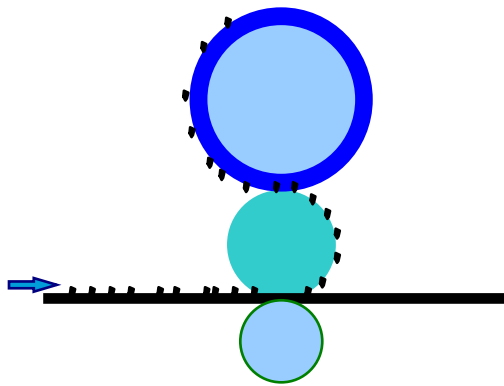
Options for cleaning polymer film surfaces

- Cloth wipe
 - Static brush
 - Rotating brush
 - Air blower / knife
 - Vacuum cleaner
- Surface contact can cause damage
- Difficult to breakthrough entrained air
- Electrostatic neutralised ultrasonic pulsed air jet & vacuum extract
 - Transfer tack rolls
 - Planarization and/or Overcoating
(best combined with pre-cleaning first)
 - Carbon Dioxide ‘snow jet’

Polymer pre-layer

No cleaning
requires thick
coating

Large debris

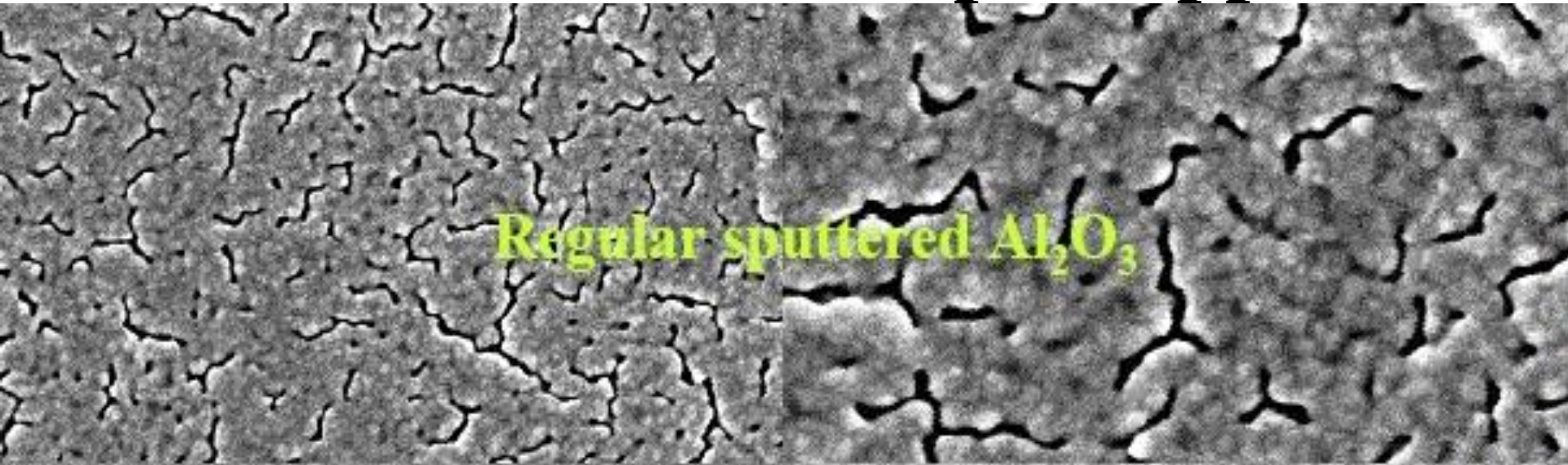


+



Cleaning = fewer, smaller debris & thinner coating

General Atomics – Super sapphire



FEI03LFP0

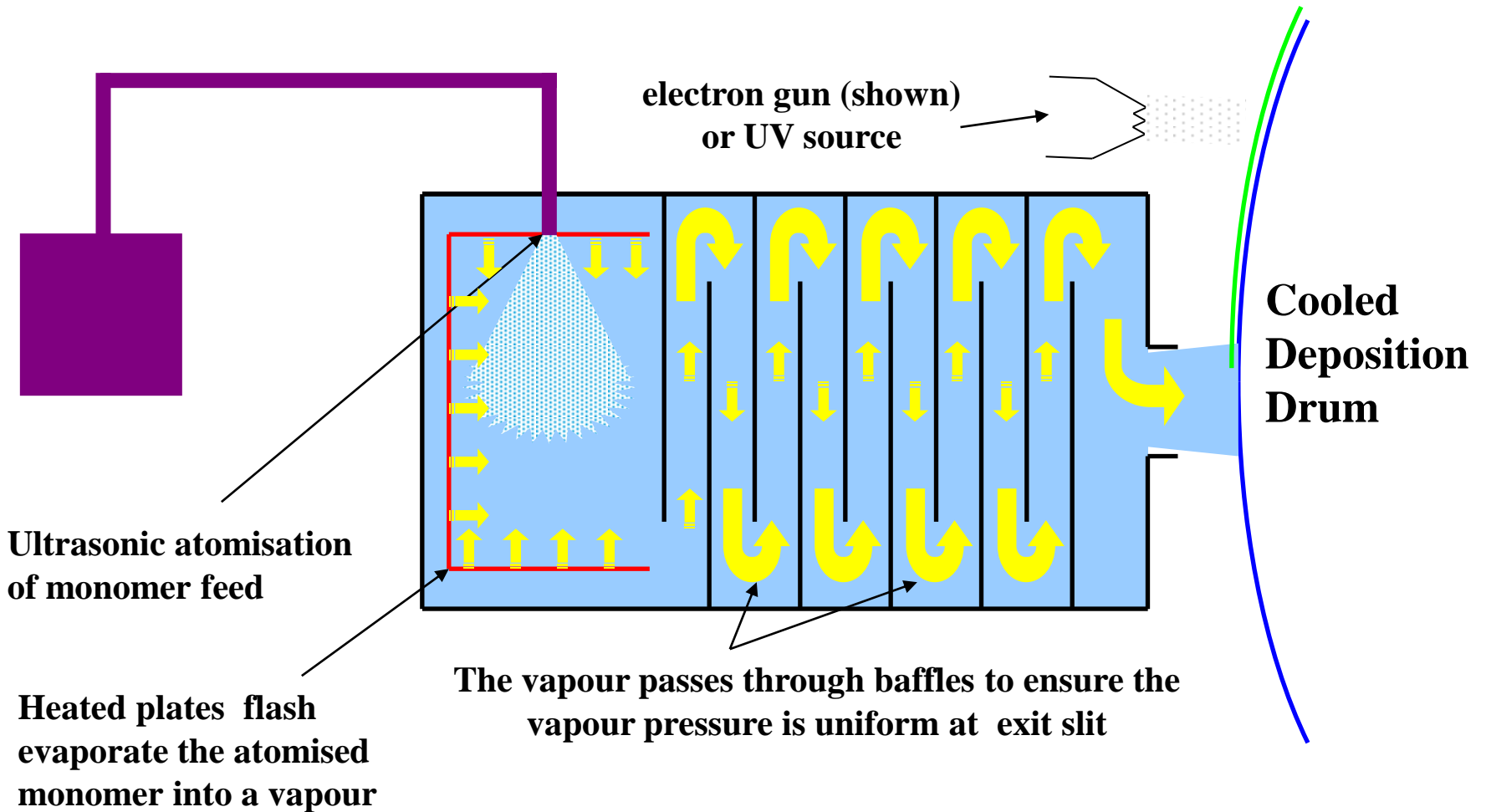
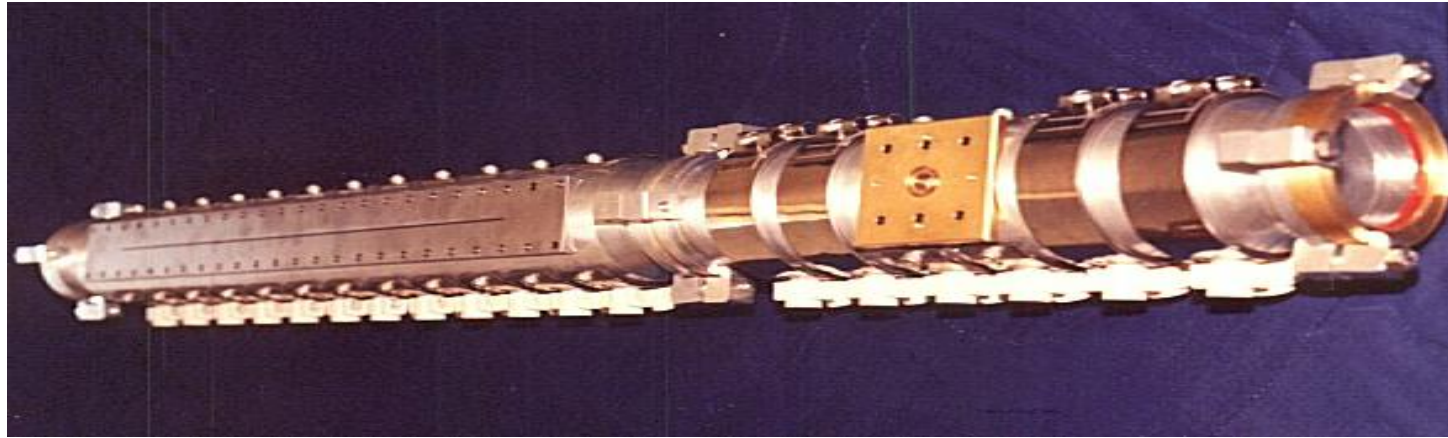
INRF 15.0kV 5.6mm x200k

200nm

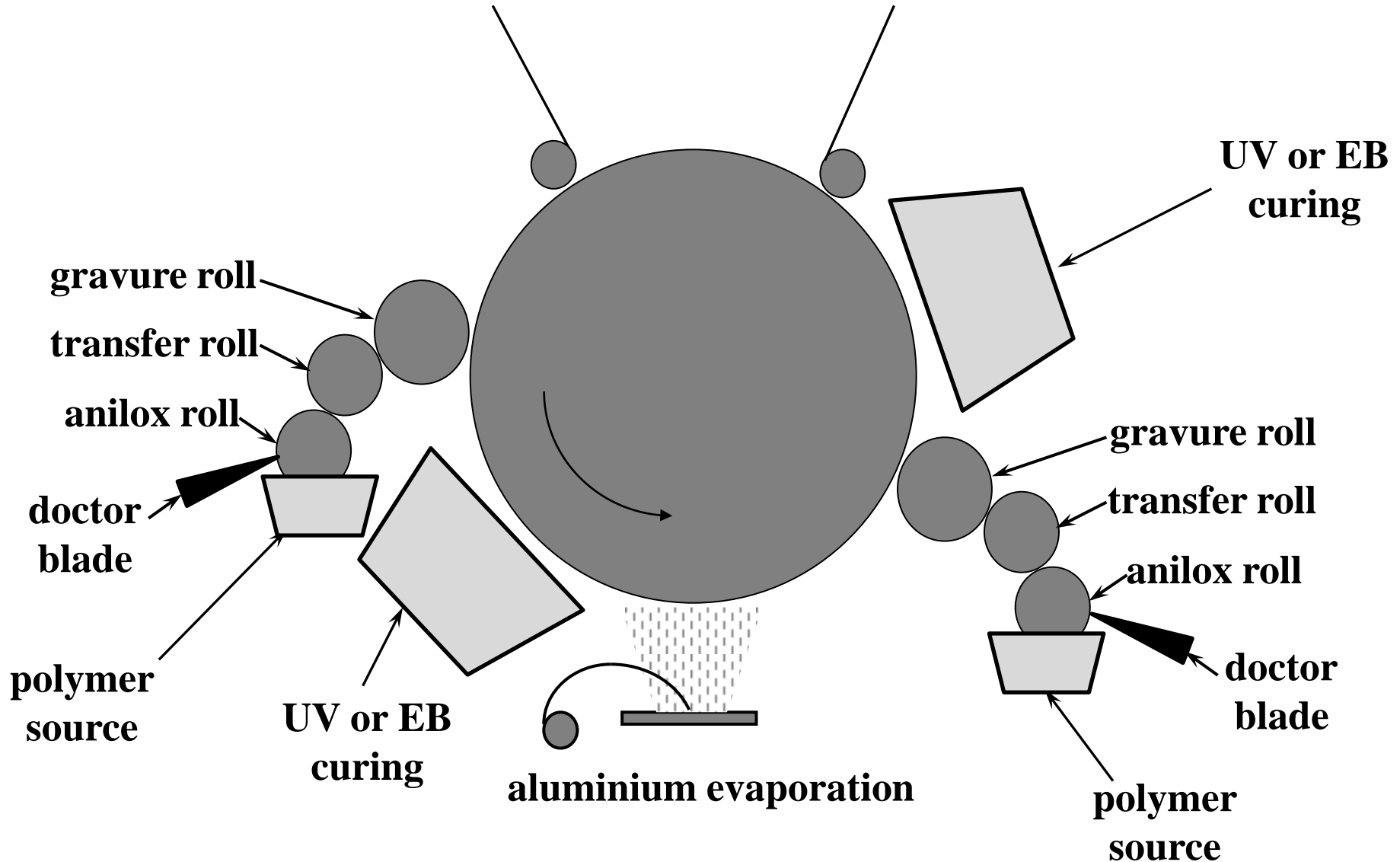
FEI03LFP0

INRF 15.0kV 5.6mm x300k

100nm

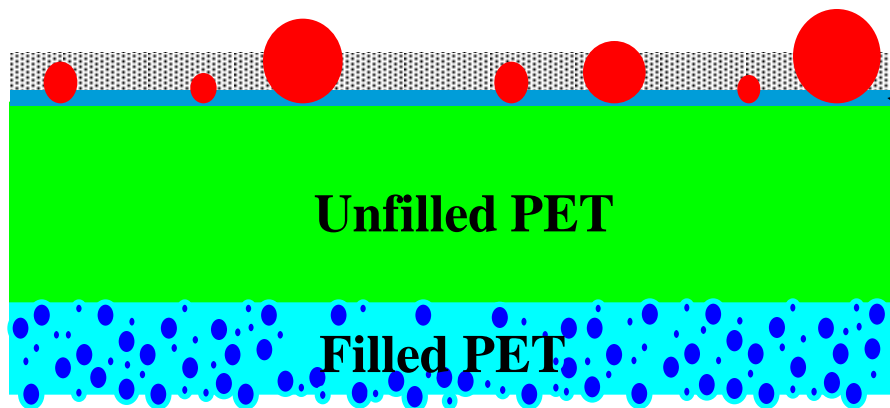
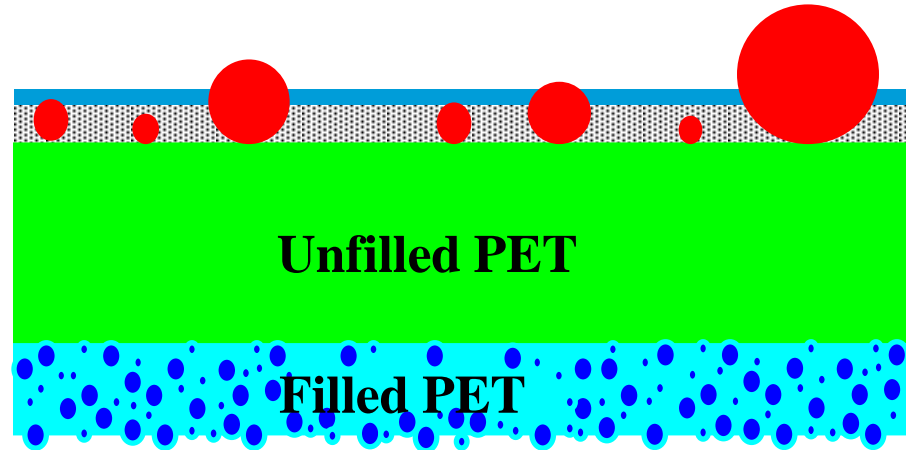


Pre / Post Acrylate Monomer Printing



Polymer layers

Sigma International - Benefits of polymer layers.	
Materials	No.pinholes/unit area
OPP + Al	1760
OPP + Polymer + Al	590
OPP + Al + Polymer	35

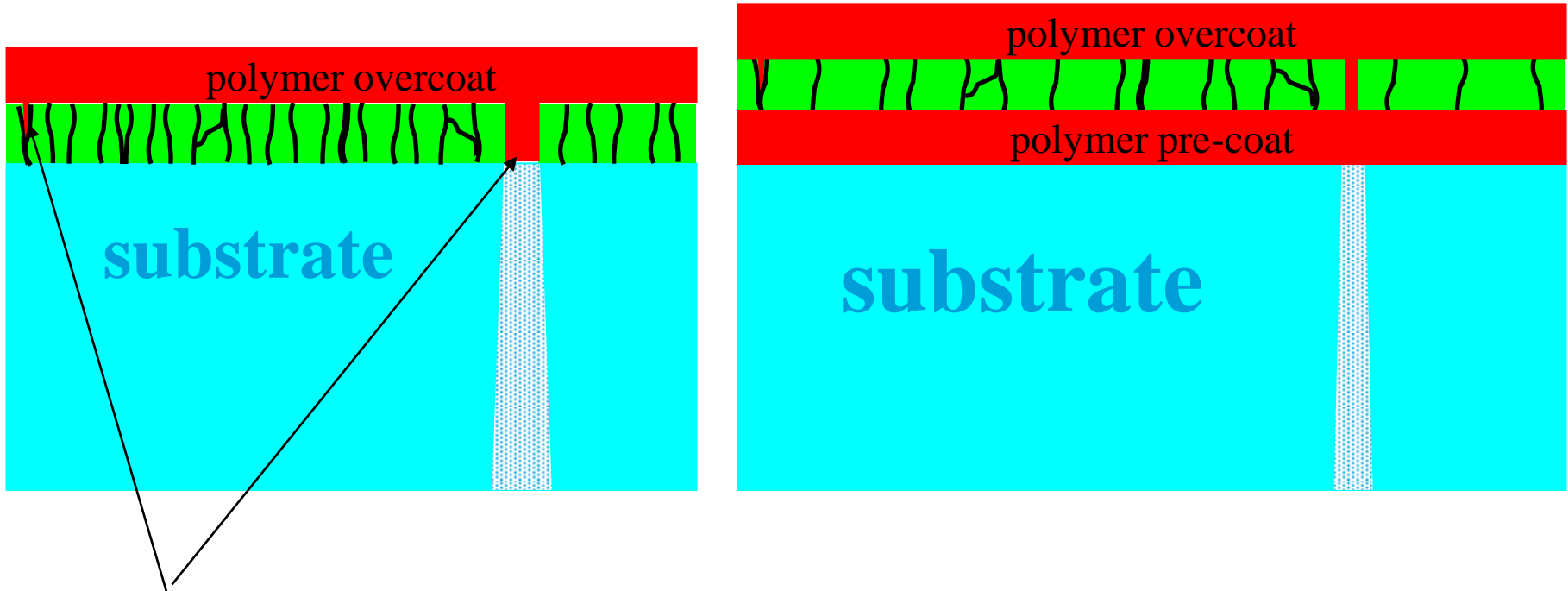


Polymer acrylate

Aluminium

Acrylate hides some debris & prevents some others from being moved. If debris is moved the polymer protects the metal coating

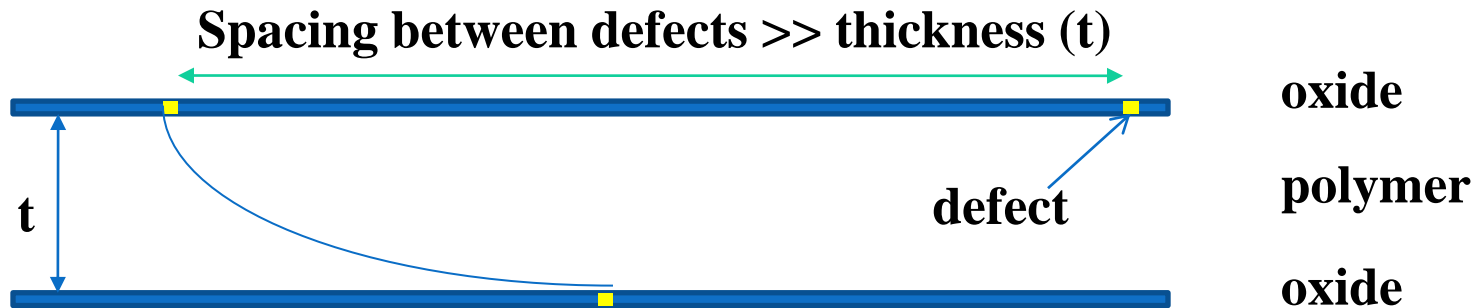
Defects



The polymer is drawn by capillary action into pores thus partially sealing them. Adding a nano-flake further improves the diffusion coefficient of the coatings. Ideally the flake size is small enough to fill and plug any cracks, pores or pinholes in the coating.

Barrier performance

Aluminised PET (single)	~ 30nm	0.31 - 1.55	0.31 - 1.55	Evaporation	Al
Aluminised PET (double)	~ 30nm each	0.03	N/A	Evaporation	Al

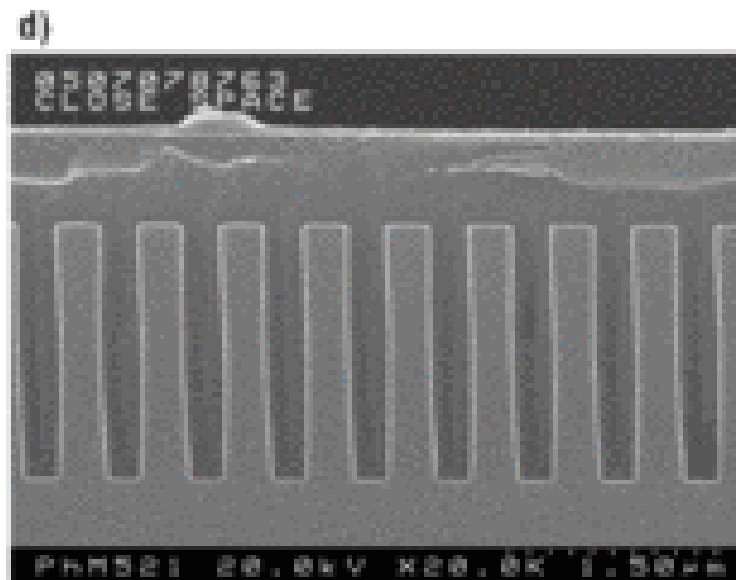
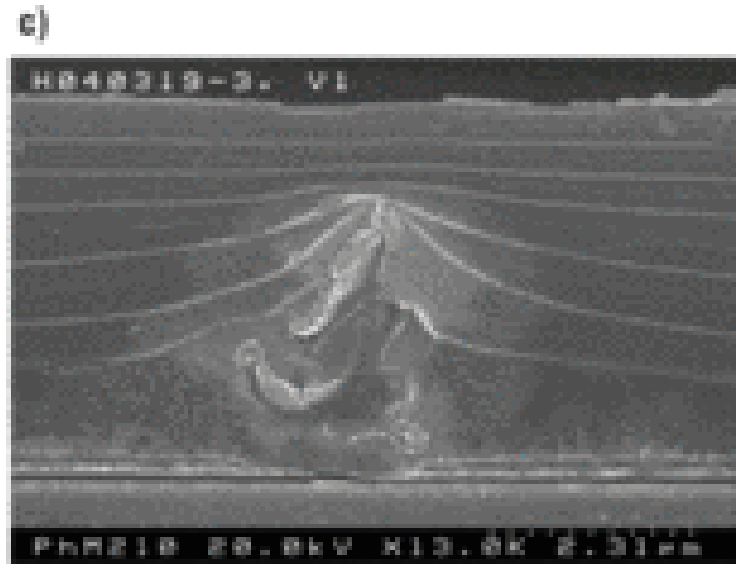
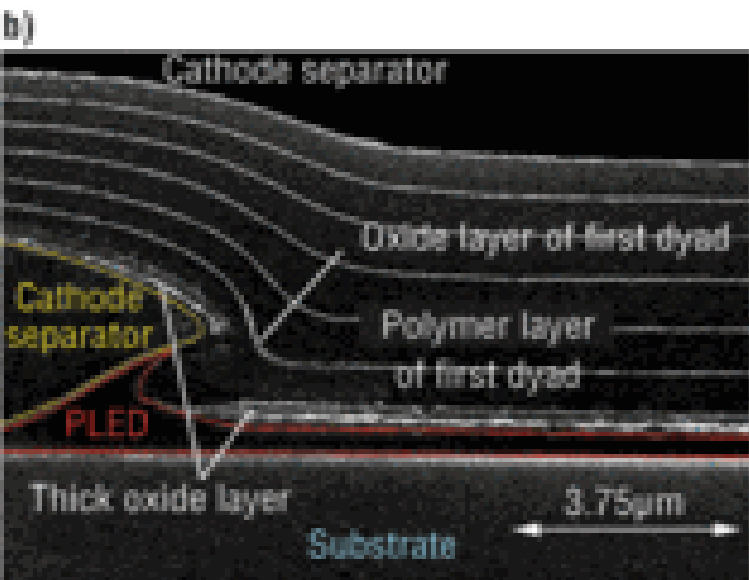
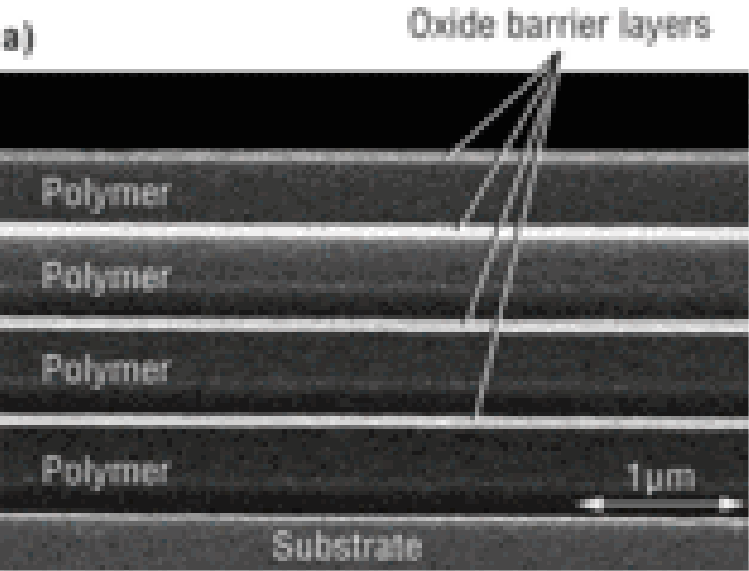


When the defect spacing is large compared to the thickness the diffusion path becomes very long as shown above

By comparison a greater density of defects results in the diffusion distance being \sim = equal to the polymer thickness



Polymer / oxide barriers - Barix



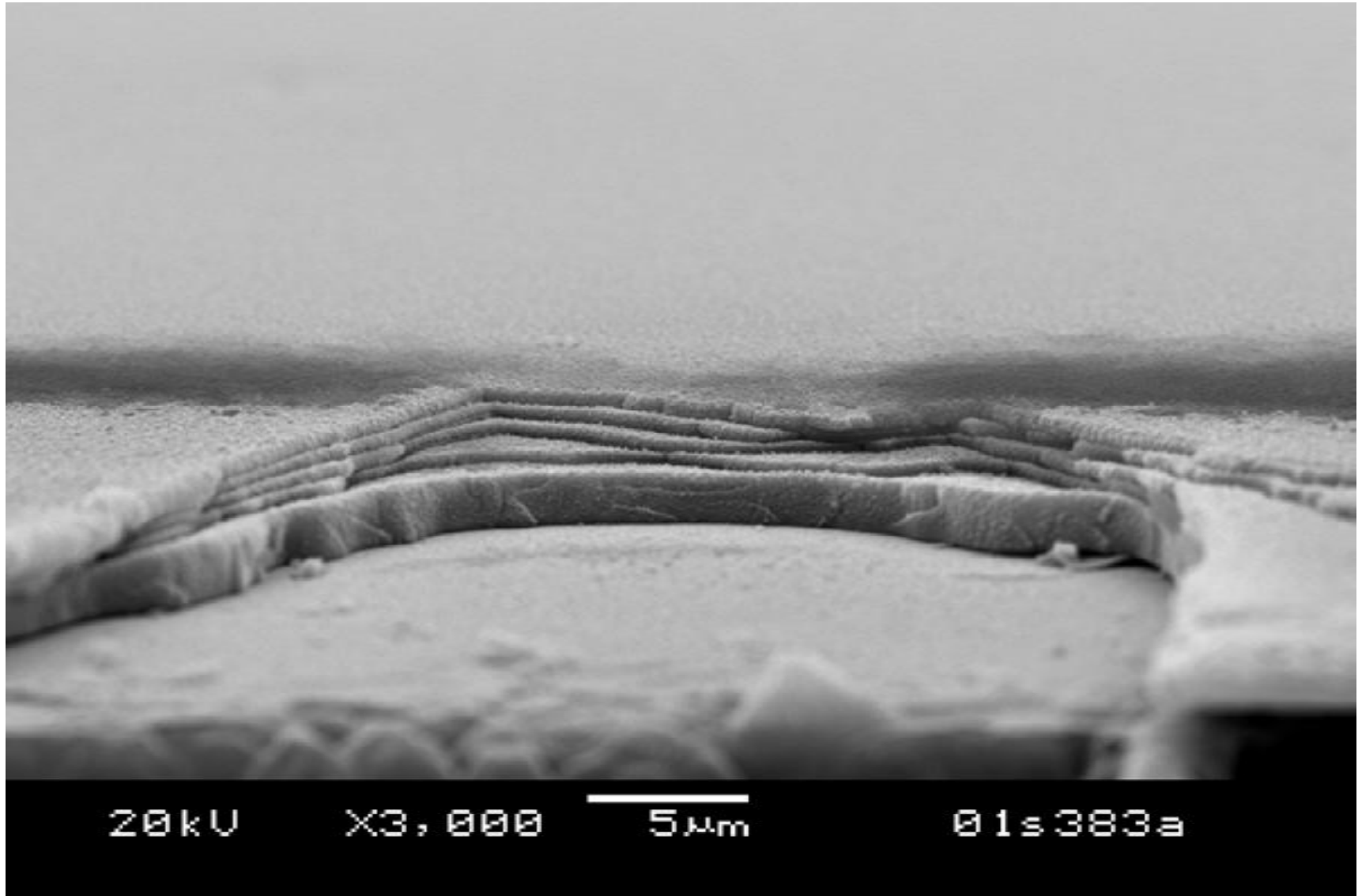
a) Basic 4 dyad structure

b) Barrier structure on OLED cathode

c) Barrier structure on substrate defect

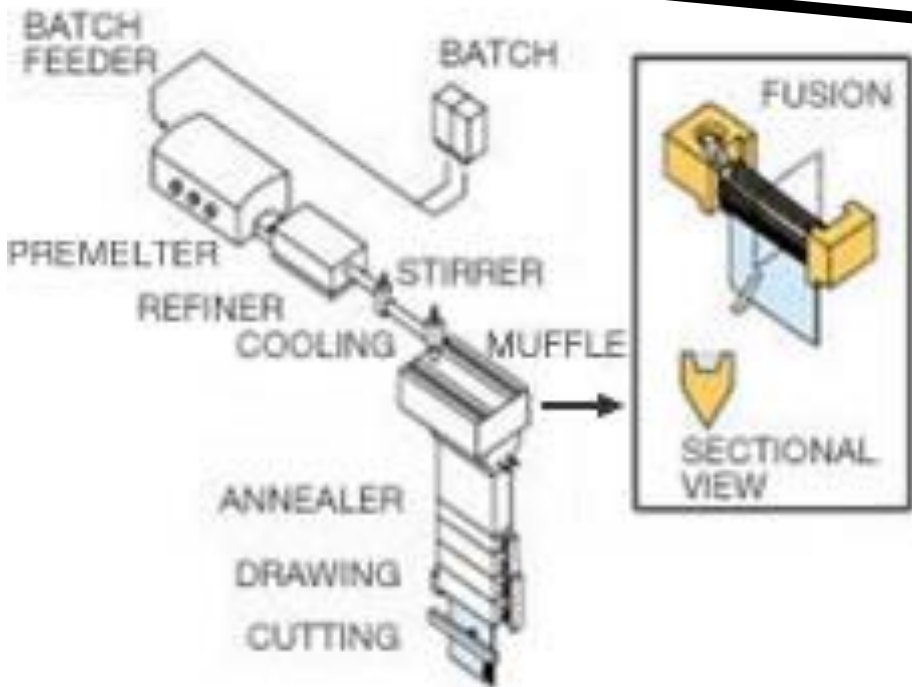
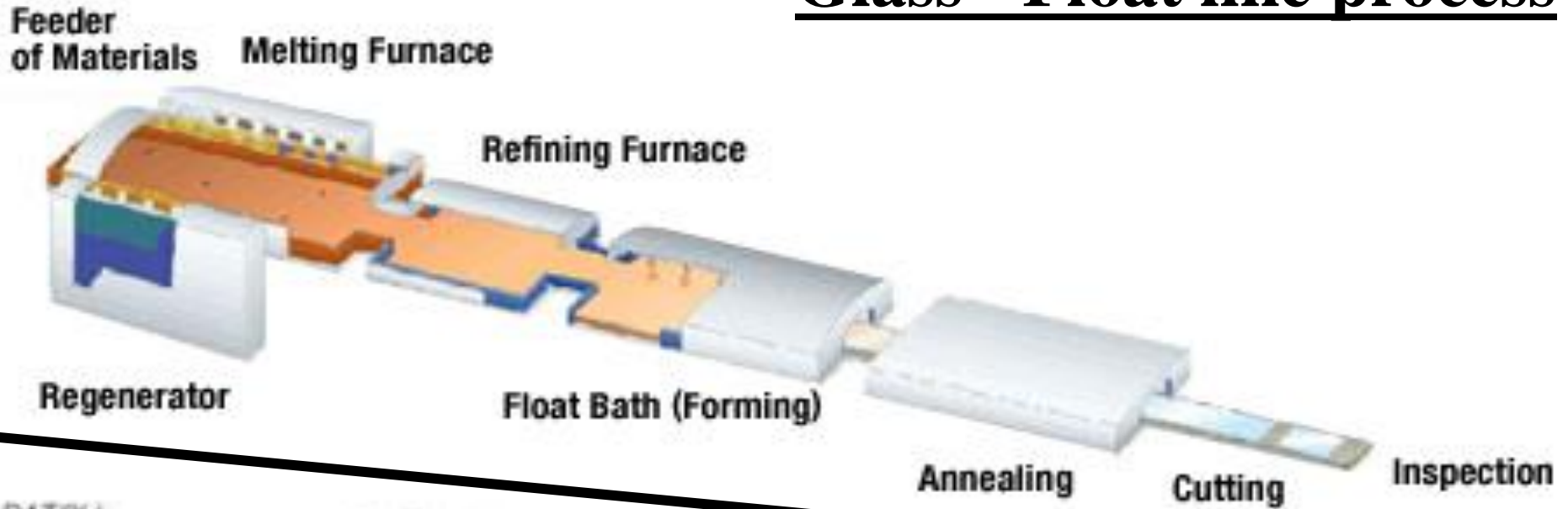
d) Basic polymer planarization layer on a test grating to evaluate planarising effect

Multi-dyad barrier



Fracture cross-section SEM of generic Barix™ film

Glass - Float line process



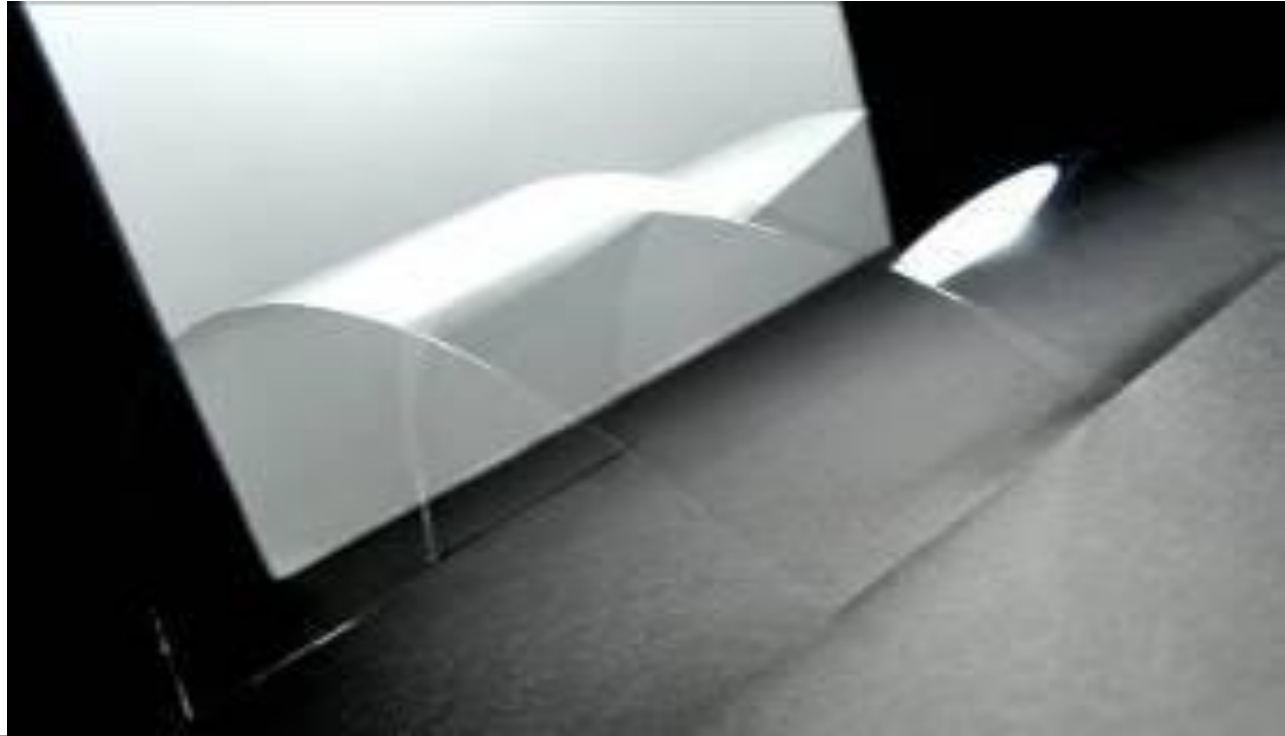
Fusion process

Rolls of glass down to
50 microns thick

Glass substrates

30 microns (R &D)

**50 microns pilot
production**



**The photograph from
Corning shows the
edges protected by
Kapton tape**

Conclusions

Key to good barrier:

Substrate quality

Surface – clean, smooth, flat, minimal defects

Bulk - thermally stable, good gauge, well wound

zero or minimal exudate contamination

If you do not get the substrate right – do not bother coating

Deposition process

High quality winding – tension control

Good quality deposition system hygiene

Dense coating – minimise defects

Maximise adhesion

Minimal front surface contact – protect coating

High quality handling & storing rolls

} Manage substrate surface

Conclusions

All webs are contaminated with debris (both sides)

Most webs would benefit from a physical clean such as by tack-roll (both sides)

Many would also benefit from a molecular clean
to raise the surface energy
to modify chemistry to improve adhesion

Alternative strategy - cover debris using polymer coating - coating may also need plasma treating

Densify coating – minimise porosity & defects



CONSULTING LTD

Thank you for listening

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